



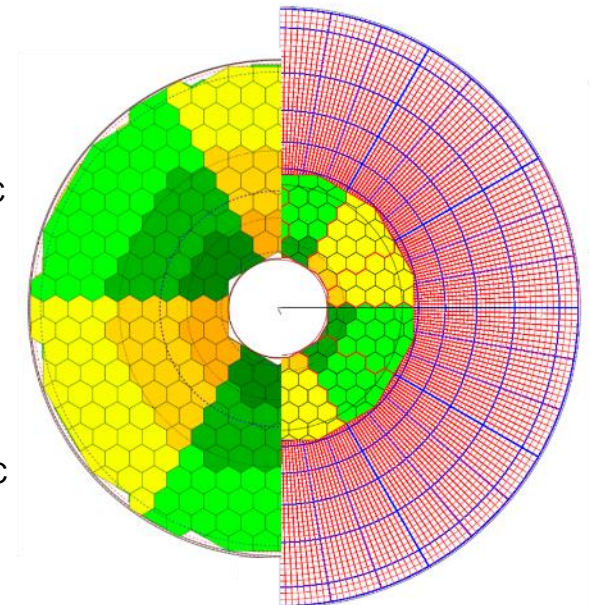
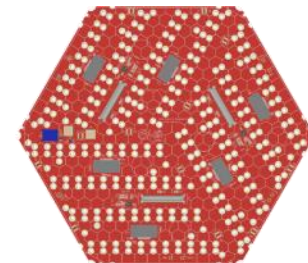
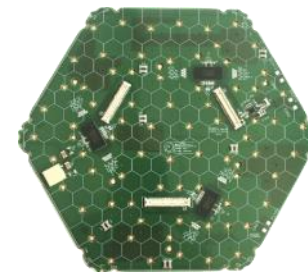
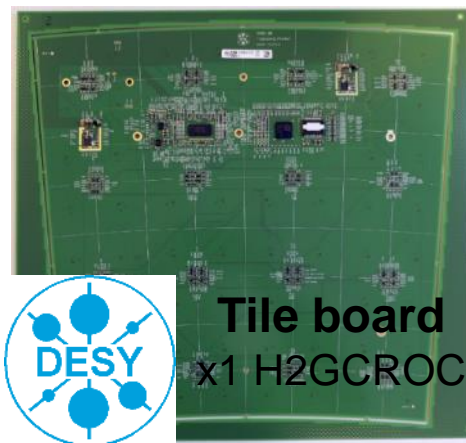
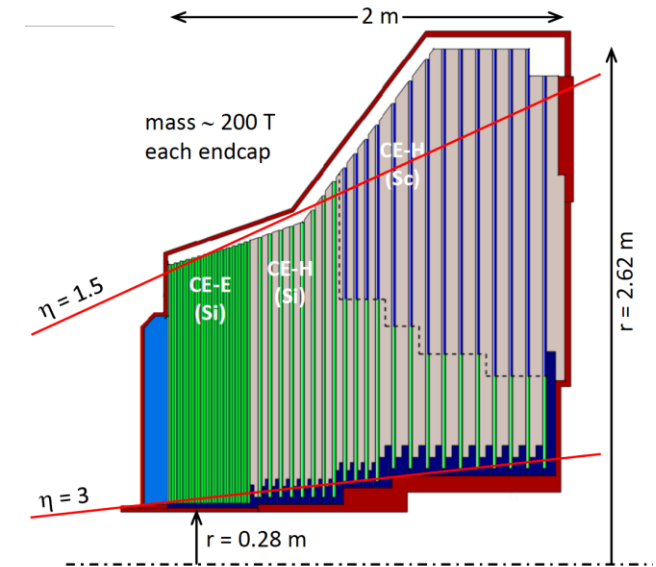
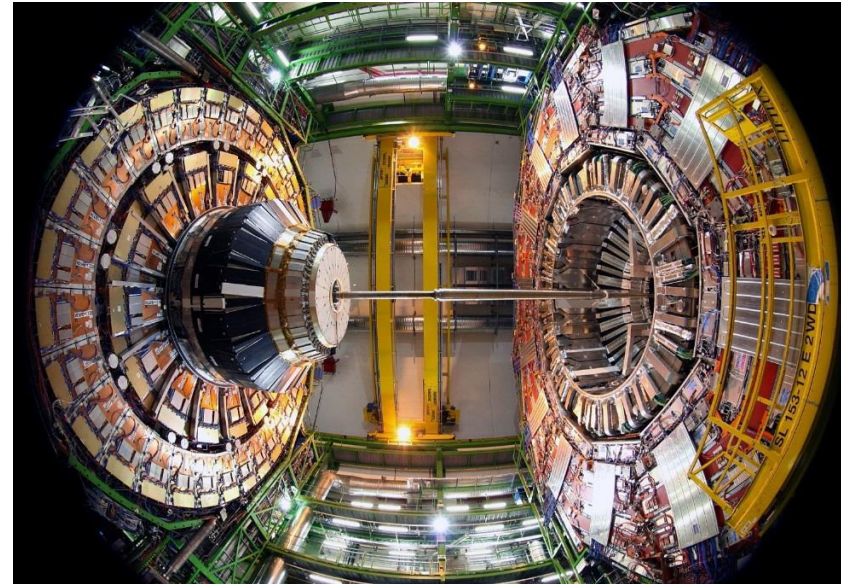
The HGCRROC for CMS high granularity calorimeter

G. Bombardi, F. Bouyjou, E. Delagnes, P. Dinaucourt, F. Dulucq, M. El Berni, M. Firlej, T. Fiutowski, J. Gonzalez, F. Guilloux, M. Idzik, C. de La Taille, A. Marchioro, J. Moron, L. Raux, K. Swientek, D. Thienpont, T. Vergine

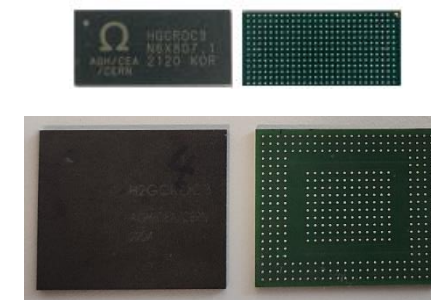
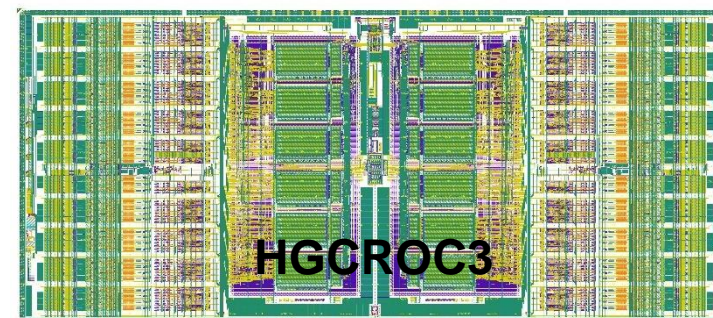
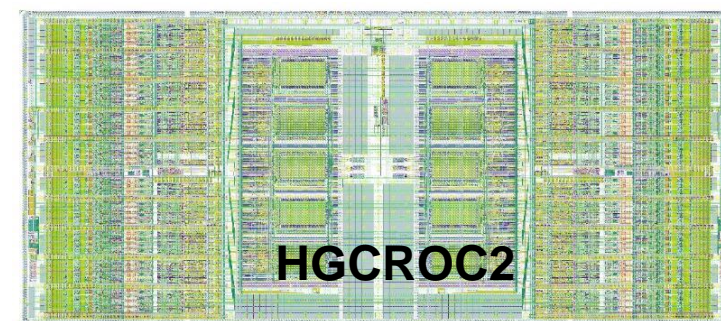
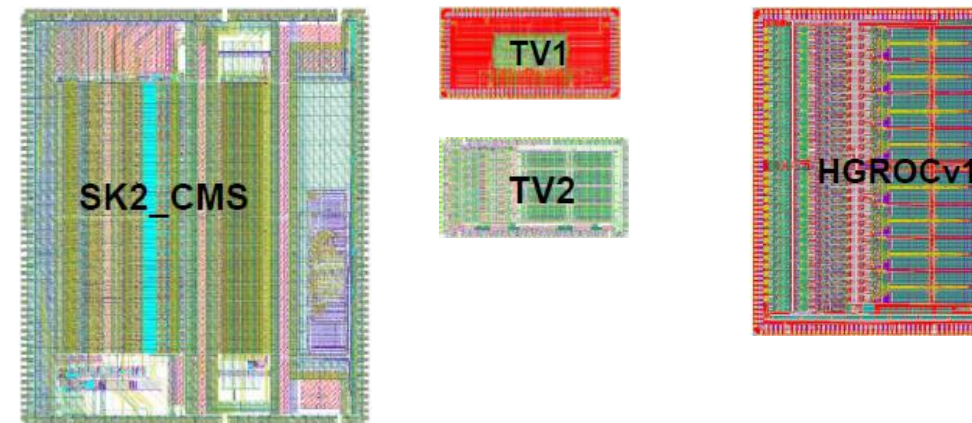
June 15, 2023



- ❑ HGCAL covers $1.5 < \eta < 3.0$
- ❑ Full system maintained at -30°C
 - ❑ $\sim 640 \text{ m}^2$ of silicon sensors, 6.1M Si channels, 0.5 or 1.1 cm^2 cell size
 - ❑ $\sim 370 \text{ m}^2$ of scintillators, 240k scint-tile channels
- ❑ Data readout from all layers
- ❑ Trigger readout from alternate layers in CE-E and all in CE-H
- ❑ Active Elements
 - ❑ Electromagnetic calorimeter (CE-E): Si, Cu/CuW/Pb absorbers
 - ❑ Hadronic calorimeter (CE-H): Si & scintillator, steel absorber
- ❑ New Front-end electronics
 - ❑ Two versions: Silicon and SiPM
 - ❑ Rad.tolerant (200 Mrad, 1.1016 neq / cm^2)
 - ❑ Power consumption: 15 mW per channel
 - ❑ Noise: 0.4 fC
 - ❑ Charge: 0.2 fC to 10 pC
 - ❑ Pileup mitigation: Fast shaping (peak < 25 ns), precise timing capability (25 ps)



- Jan 16: **SKIROC2_CMS** [TWEPP 2016]
 - SiGe 350 nm 7x9 mm²
 - Dedicated to test beam and analog architecture (TOT)
- May 16: 1st test vehicle **TV1**
 - CMOS 130 nm 2x1 mm²
 - Dedicated to preamplifier studies
- Dec 16: 2nd test vehicle **TV2** [TWEPP 2017]
 - CMOS 130 nm 4x2 mm²
 - Dedicated to technical proposal analog channel study
- July 17: **HGCROCv1** [TWEPP 2018]
 - CMOS 130 nm 5x7 mm²
 - **Wire bonds**
 - All analog and mixed blocks; large part of digital blocks
- Feb 19: **HGCROC2** [CHEF 2019, IEEE 2020, TIPP 2021]
 - CMOS 130 nm 15x6 mm²
 - **Bump bonds**
 - Silicon and SiPM versions (for both 2 and 2A)
 - Final size, packaging and I/Os
- Dec 20: **HGCROC3** [TWEPP 2021, IEEE 2021]
 - CMOS 130 nm 15x6 mm²
 - **Bump bonds**
 - Silicon and SiPM versions
- June 23: **HGCROC3b**
 - CMOS 130 nm 15x6 mm²
 - Pre-production



High Density (HD) and Low Density (LD) packages

Overall chip divided in two symmetrical parts

- 1 half is made of:
 - 39 channels: 18 ch, CM0, Calib, CM1, 18 ch (78 channels in total)
 - Bandgap, voltage reference close to the edge
 - Bias, ADC reference, Master TDC in the middle
 - Main digital block and 3 differential outputs (2x Trigger, 1x Data)

Measurements

- Charge
 - ADC (AGH): peak measurement, 10 bits @ 40 MHz, dynamic range defined by preamplifier gain
 - TDC (IRFU): TOT (Time over Threshold), 12 bits (LSB = 50ps)
 - ADC: 0.2 fC resolution. TOT: 2.5 fC resolution
- Time
 - TDC (IRFU): TOA (Time of Arrival), 10 bits (LSB = 25ps)

Two data flows

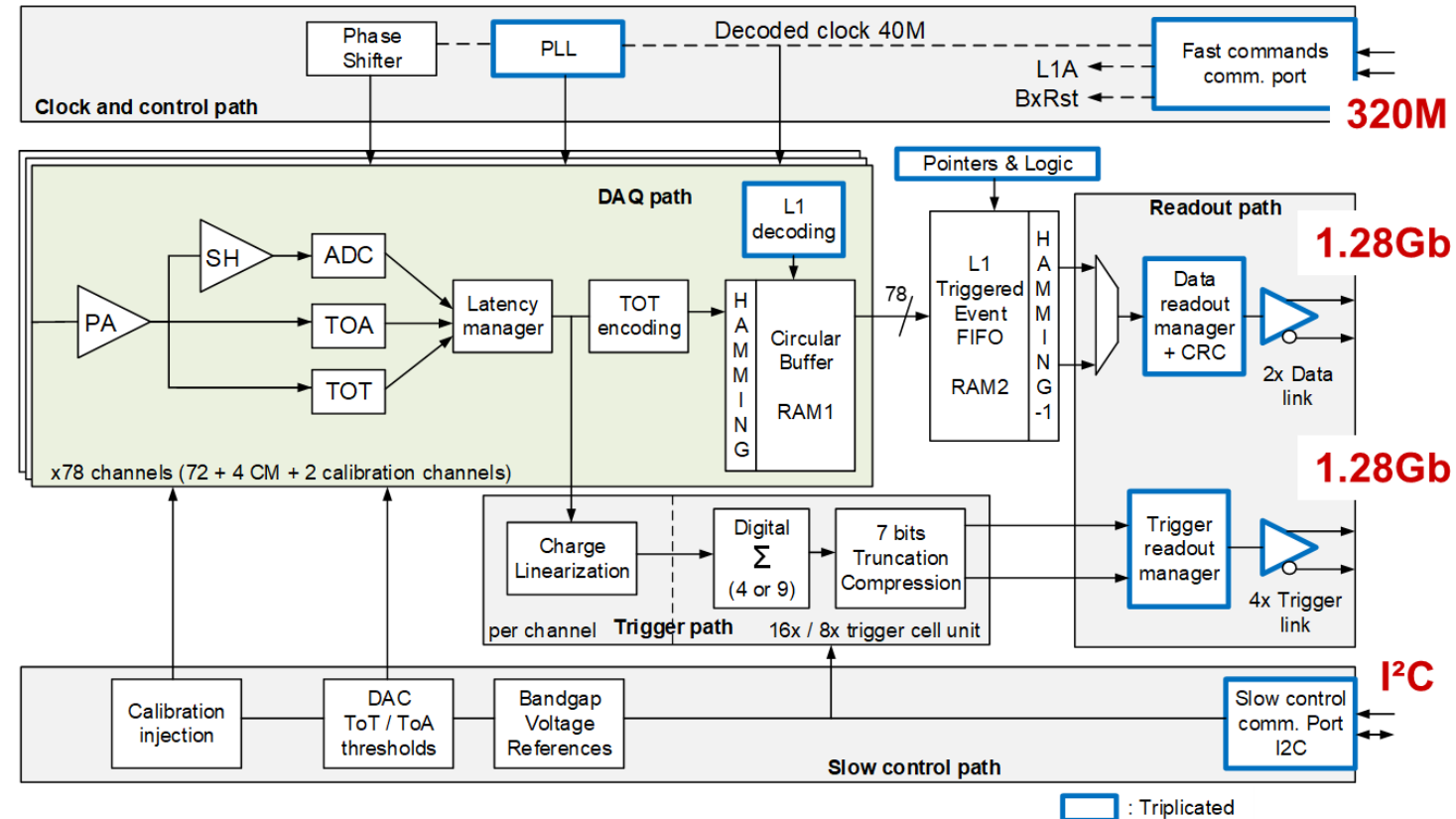
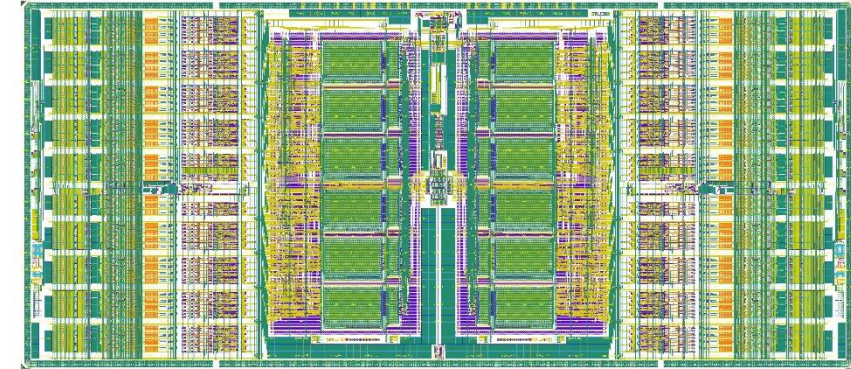
- DAQ path
 - 512 depth DRAM (CERN), circular buffer
 - Store the ADC, TOT and TOA data
 - 2 DAQ 1.28 Gbps links
- Trigger path
 - Sum of 4 (9) channels, linearization, compression over 7 bits
 - 4 Trigger 1.28 Gbps links

Control

- Fast commands
 - 320 MHz clock and 320 MHz commands
 - A 40 MHz extracted, 5 implemented fast commands
- I2C protocol for slow control

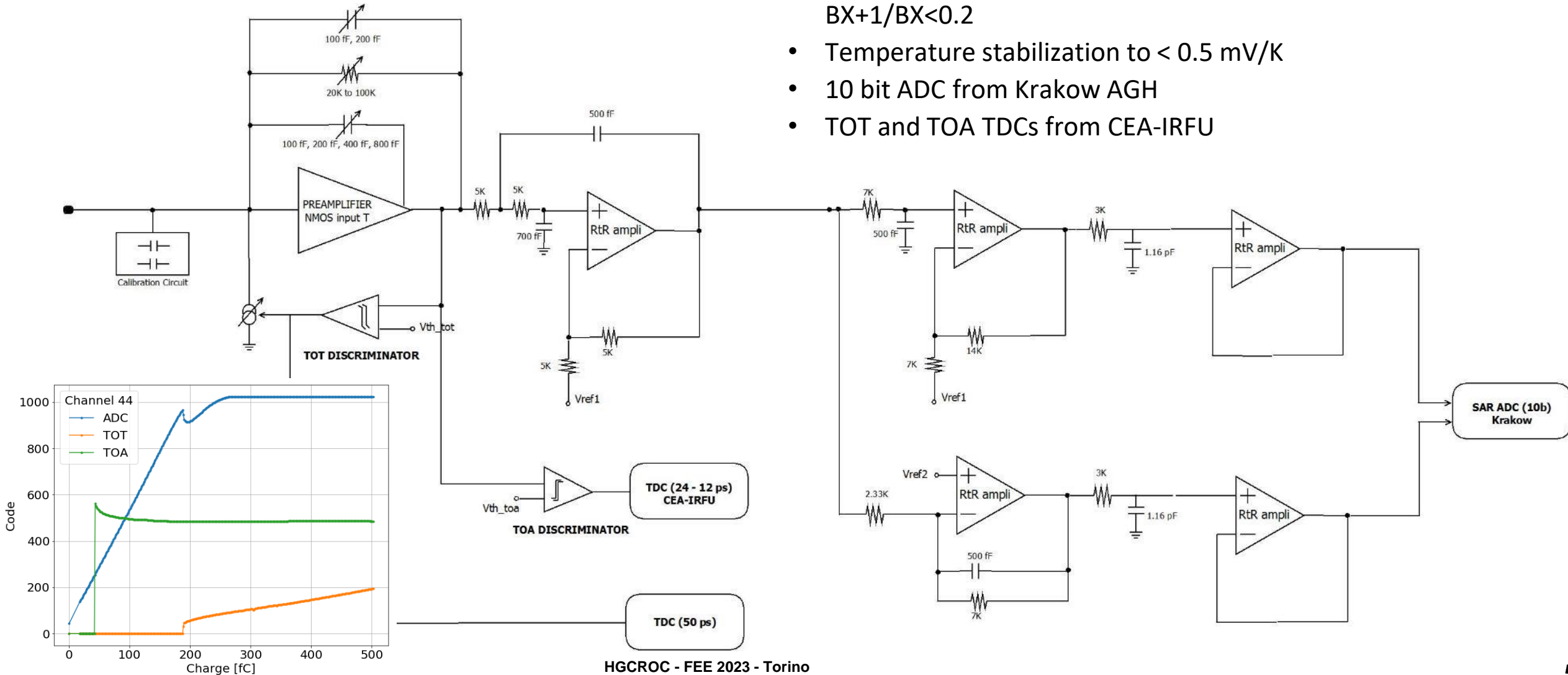
Ancillary blocks

- Bandgap (CERN)
- 10-bits DAC for reference setting
- 11-bits Calibration DAC for characterization and calibration
- PLL (IRFU)
- Adjustable phase for mixed domain

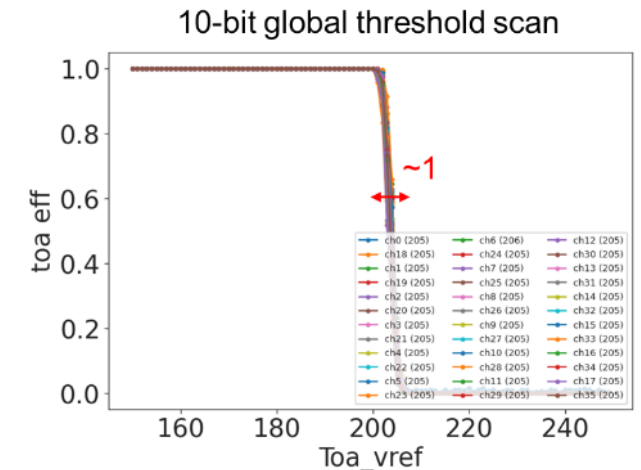
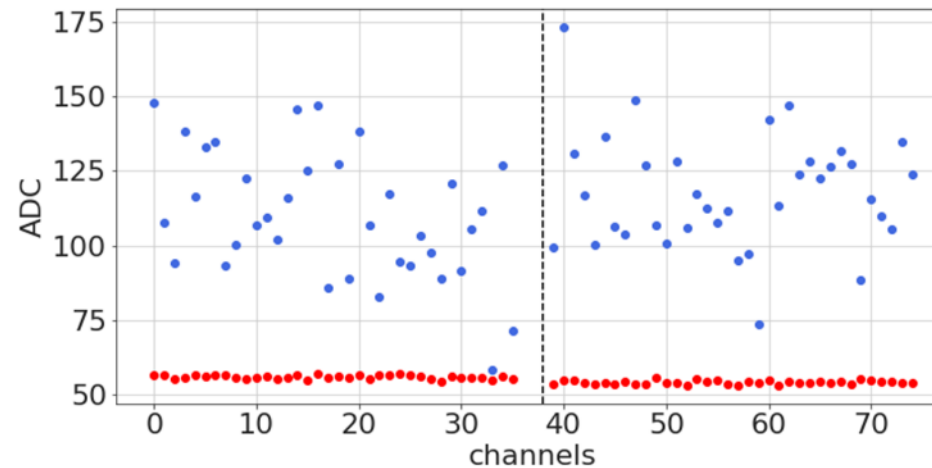
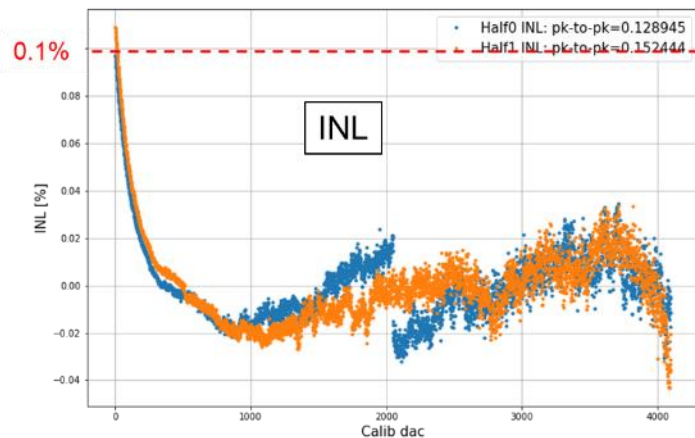


- Calibration pulser, 0.5pF and 10 pF calibration cap.
- Preamp : adjustable gains for 80, 160 and 320 fC ranges
- Tunable TOT over 5 bits

- Compensation for the leakage current, 50 μ A max. (not shown in the figure)
- Sallen Key shaper RC4, $t_p < 25$ ns, tunable ($\sim 20\%$) with 2 bits, $BX+1/BX < 0.2$
- Temperature stabilization to < 0.5 mV/K
- 10 bit ADC from Krakow AGH
- TOT and TOA TDCs from CEA-IRFU



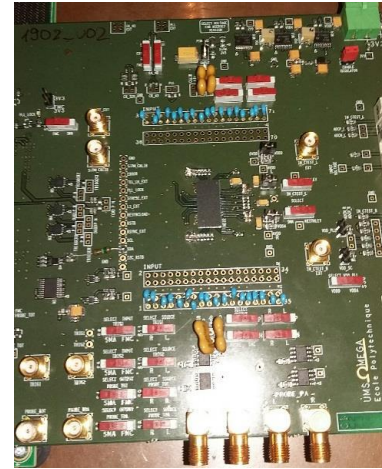
- 12 bits calibration DAC
 - ~ 2-3 mV offset due to leakage current (1 – 1.5 fC)
 - < 0.1 % linearity, temperature sensitivity: 60 ppm/K, stable after 350 Mrad
- Four 10-bit DACs to set pedestals, TOA & TOT thresholds + 3 channel-wise 6-bit DACs to reduce dispersion per channel
 - Pedestals: ~ 3 ADC counts dispersion after trimming, TOA & TOT thresholds: 1-2 DAC counts after trimming
- 8-bit input DAC to compensate for the leakage current up to 45 μ A
 - Additional noise as expected from simulation



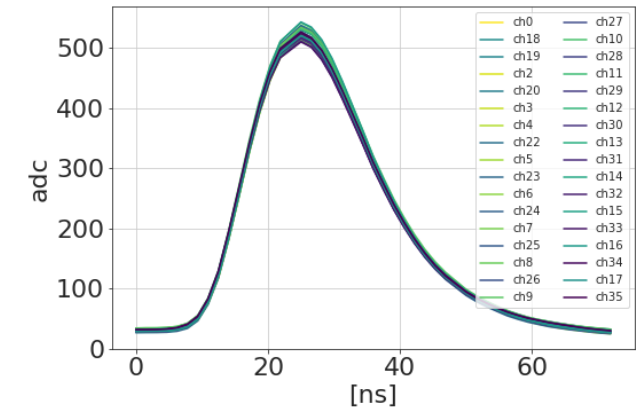
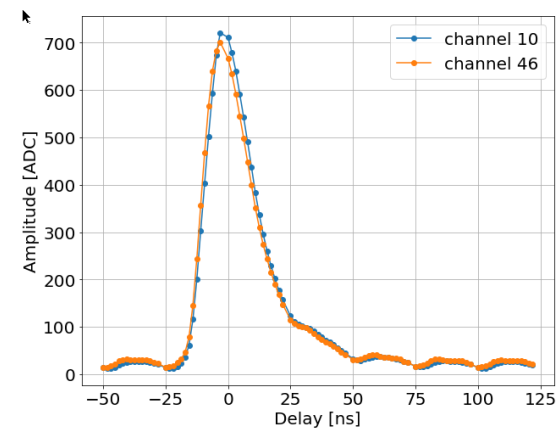
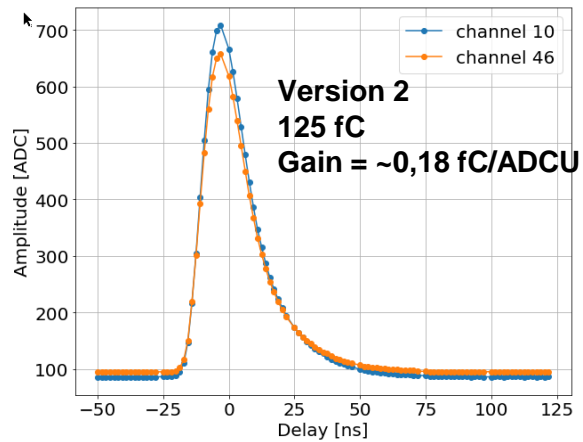
Flip-Chip on mezzanine



HD BGA board

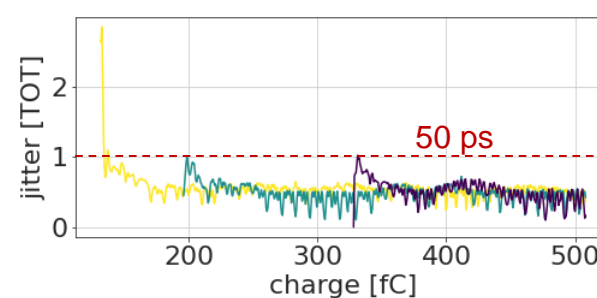
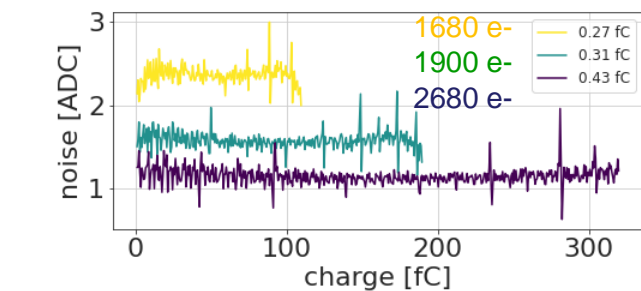
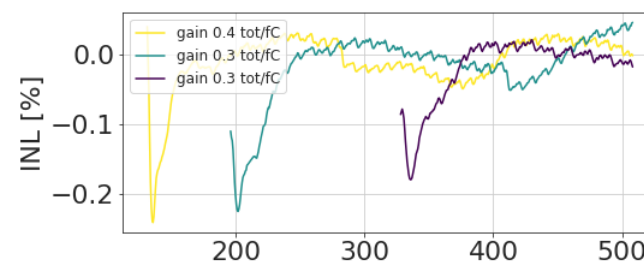
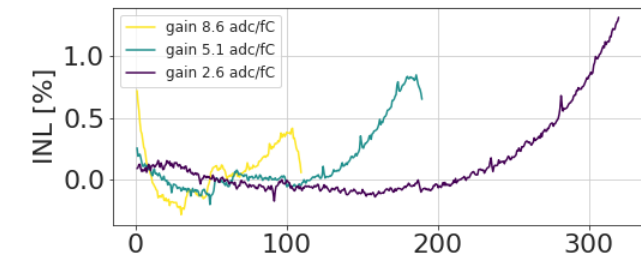
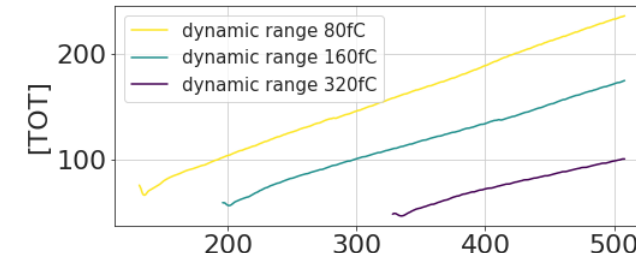
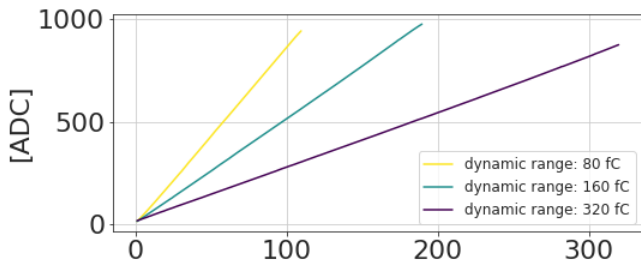
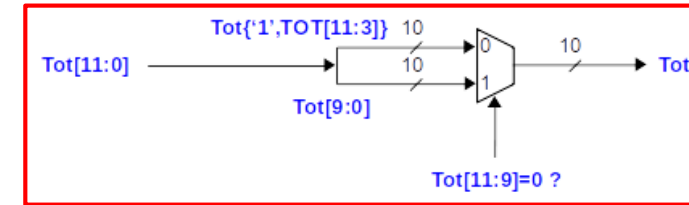


HD BGA on mezzanine

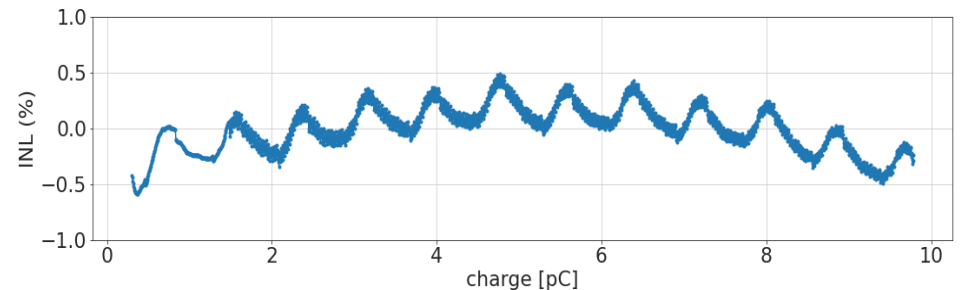
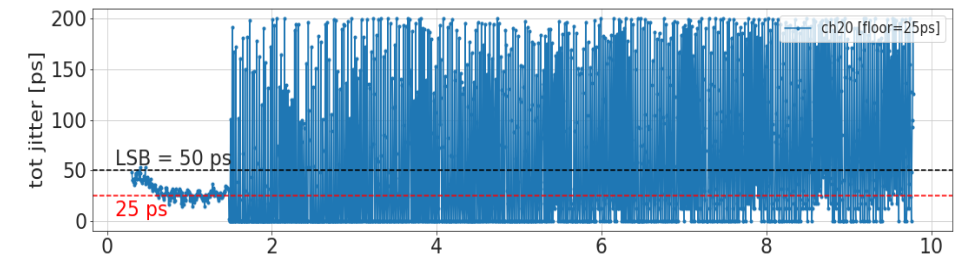
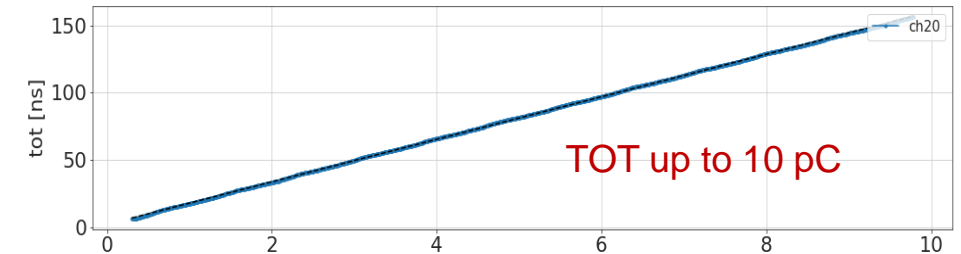


- Separates effects from the BGA substrate and PCB
- Rising time (10-90 %): ~ 15 ns
- Falling time (10-90 %): ~ 30 ns, < 20 % at BX+1
- Good uniformity over the channels
- Digital 40 MHz clock coupling on the analog inputs

- ADC range
 - Linearity in +/- 0.5 %
- TOT range
 - Linearity in +/- 0.5 %
 - Jitter around 25 ps (50 ps binning)
 - TOT 12-to-10 compression visible on the jitter
- Crosstalk: ~ 1-2% with internal injection (positive), < 0,2% with external injection from pulse (negative)



TOT linearity and jitter (w/ 47pF sensor capacitance)



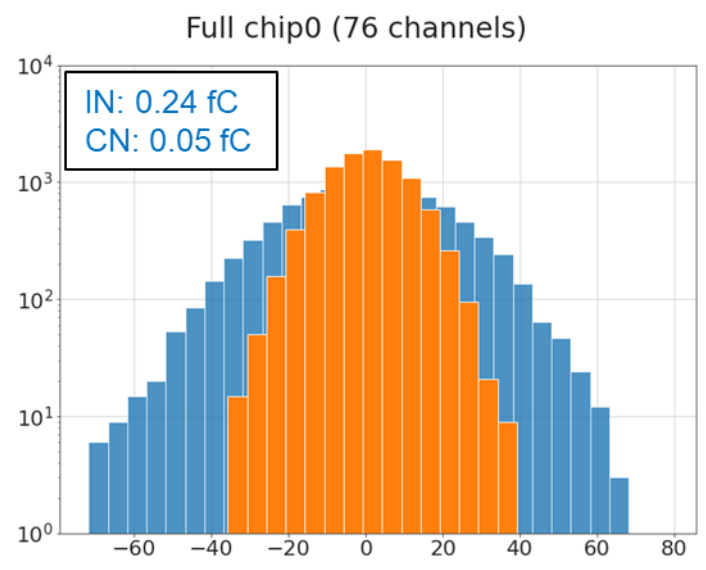
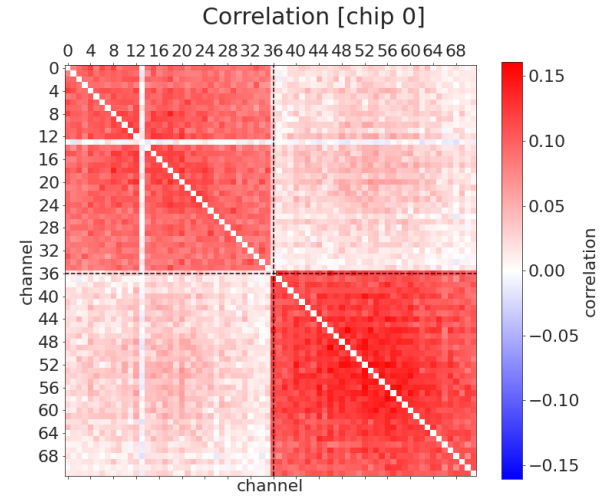
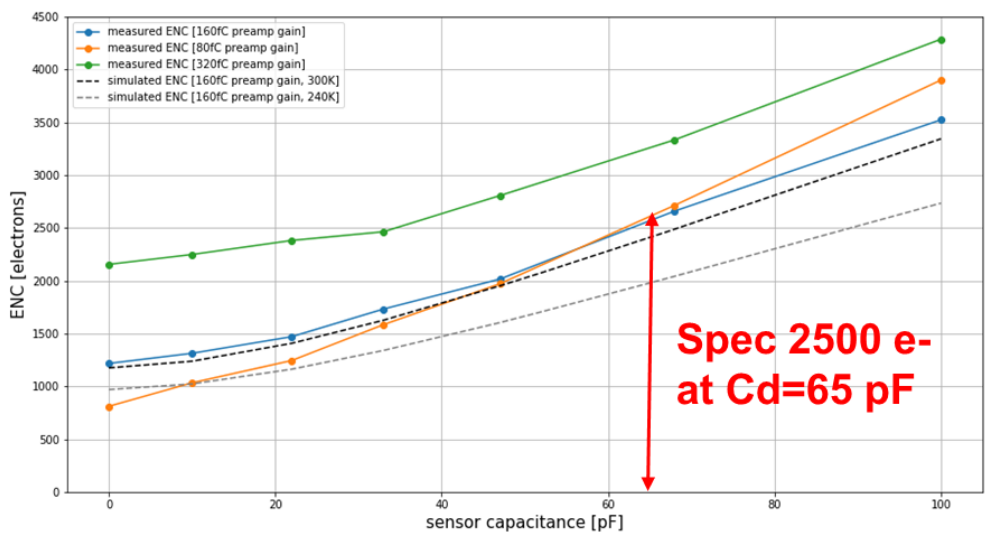
- Measured noise with 50 pF input cap: **< 0.3 fC (< 2000 electrons)**

$$ENC^2(C_d) - ENC^2(0) = \sim 3E^4 * e_n^2 \frac{(C_d^2 + C_d * C_{pa})}{t_p} \quad (t_p = 18 \text{ ns})$$

- Series noise extracted as $e_n = 0.79 \text{ nV}/\sqrt{\text{Hz}}$ and $C_{pA} = 12.6 \text{ pF}$ (simulation gives $0,75 \text{ nV}/\sqrt{\text{Hz}}$ and 11 pF)
- Preamp contributes to $\sim 75\%$ to total noise
- Very low correlated noise contribution: **$\sim 0.05 \text{ fC}$**
- Coherent noise extracted by comparing direct and alternate sums on n channels ($n = 72$):

$$DS = \sum ped[i]; AS = \sum (-1^i) ped[i]$$

- Incoherent noise $IN = rms(AS)/\sqrt{n}$
- Coherent noise $CN = \sqrt{var(DS) - var(AS)}/n$



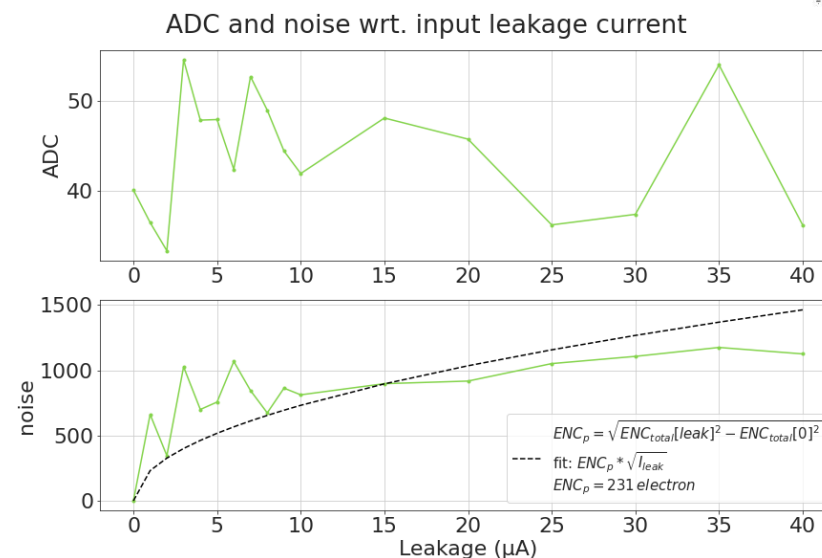
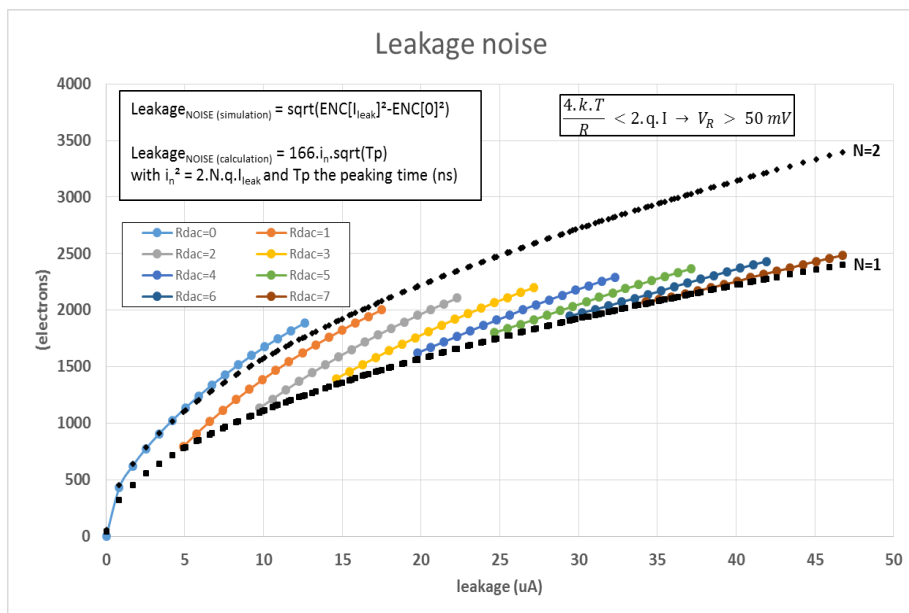
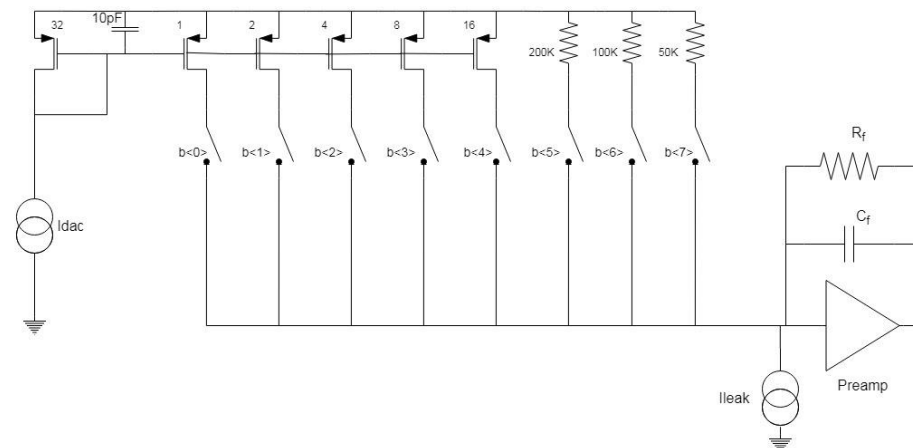
Coherent noise extracted by comparing Direct and Alternate Sums on n channels :

$$DS = \sum ped[i] \text{ and } AS = \sum (-1^i) ped[i]$$

$$IN = \frac{rms(AS)}{\sqrt{n}} \text{ and } CN = \frac{\sqrt{var(DS) - var(AS)}}{n}$$

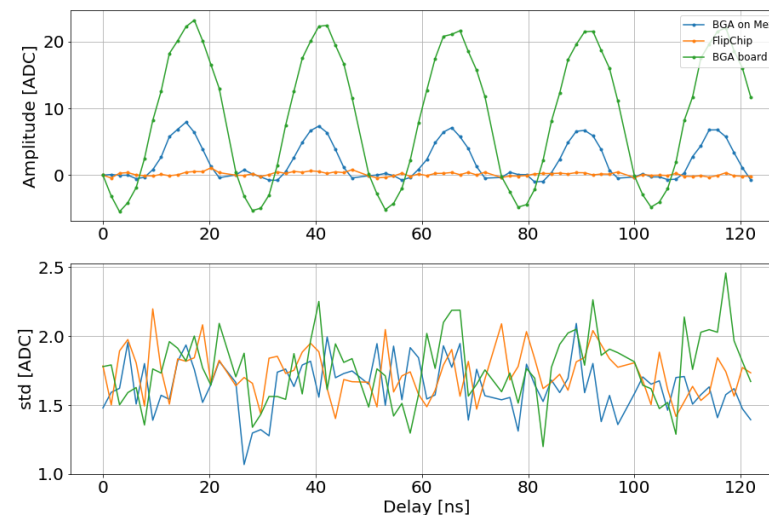
Extra noise due to Leakage current

- After irradiation, the sensor cell is expected to leak up to 50 μA
- Need to compensate for maintaining full dynamic range
 - I-Dacs: $\text{ENC}^2 = A \cdot 2 \cdot I_{\text{leak}}$
 - R-dacs: $\text{ENC}^2 = A \cdot I_{\text{leak}} + A \cdot 4kT/R$
 - At 10 μA leakage, 1550 electrons vs. 1000 electrons

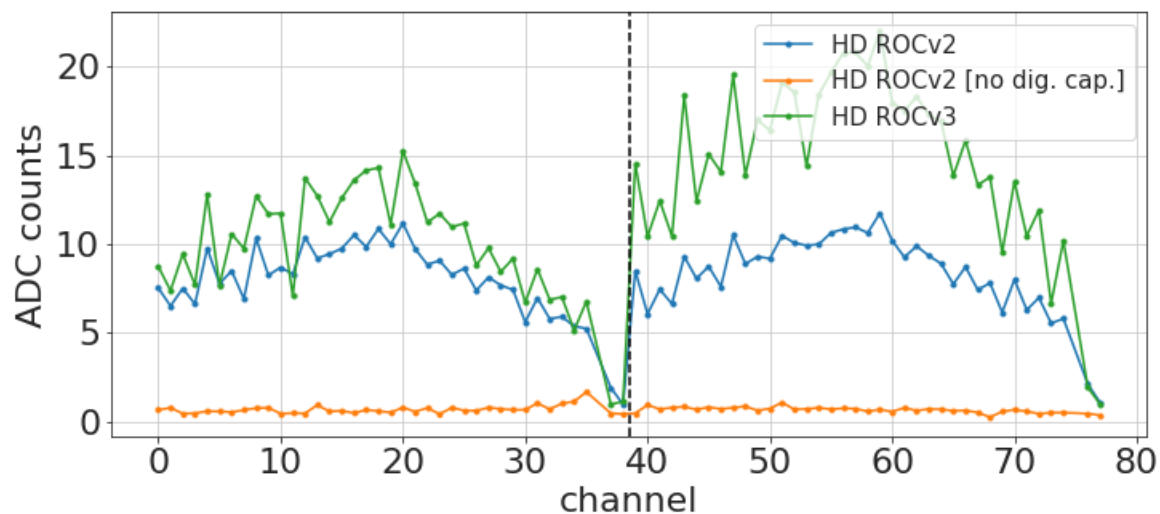


Digital modulation on mezzanine

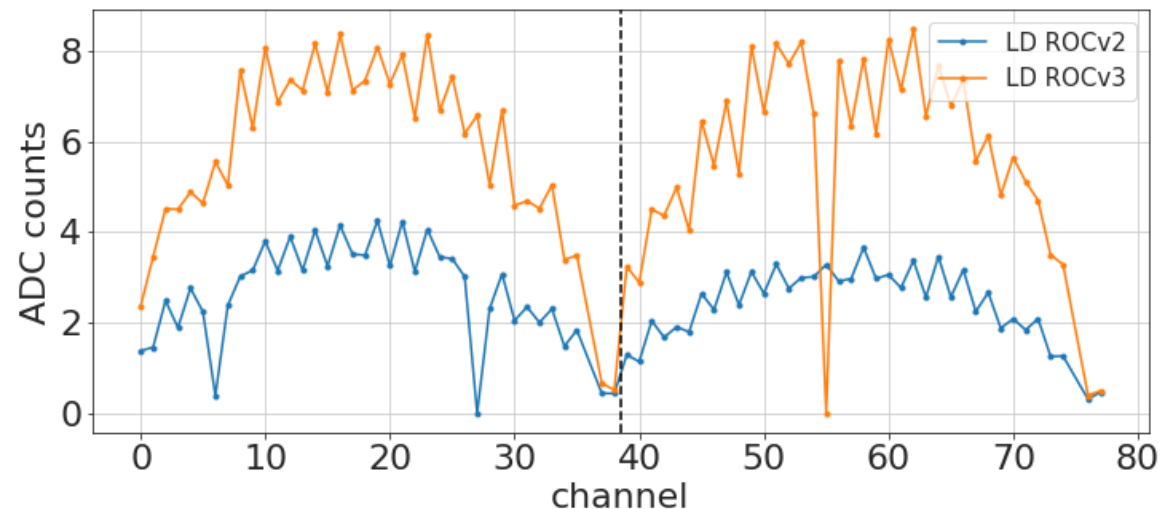
- Analog front-end very sensitive to the ground and BV
 - $\text{gain} = C_{\text{det}}/C_{\text{f_pa}} > 100$, 1 ADC count = $\sim 10 \mu\text{V}$ on ground
 - Ground: very low impedance \rightarrow planes above and below the inputs layer
- Capacitors inside the chip for decoupling VDDD
 - 2nF in HGCROC3, **16nF in HGCROC3A**
 - No obvious difference observed

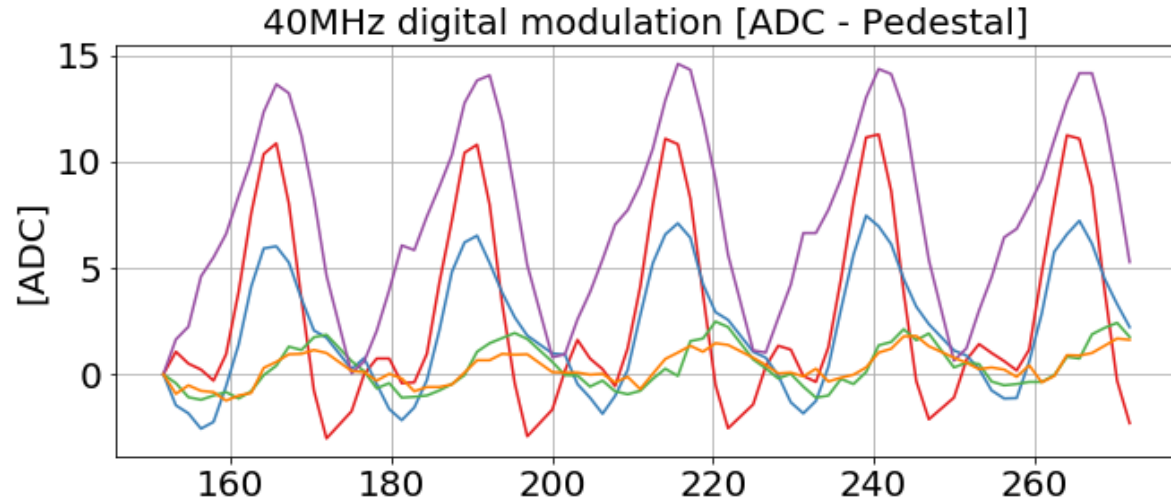


Digital coupling amplitude vs. channel

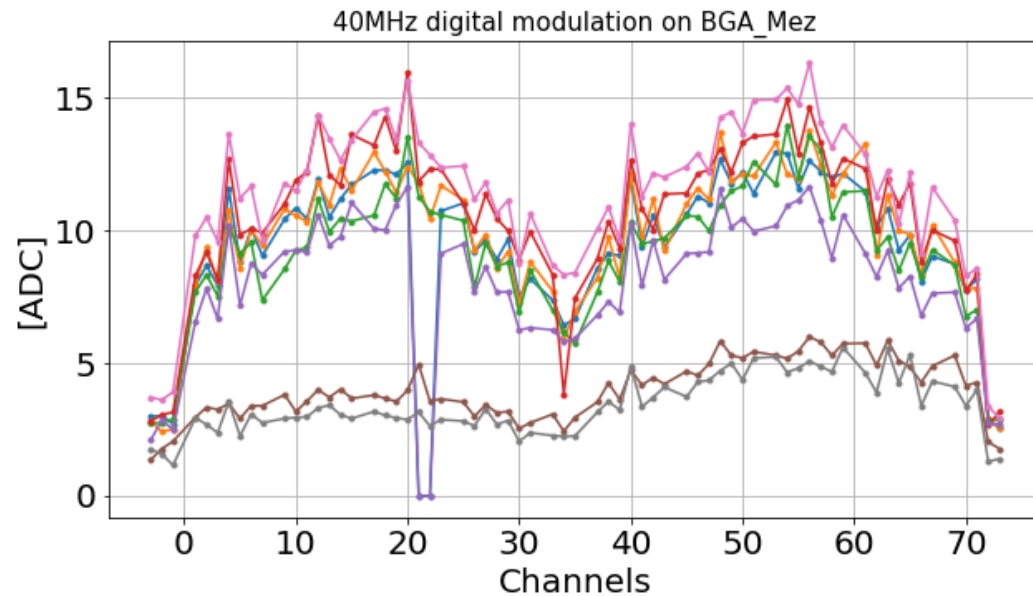
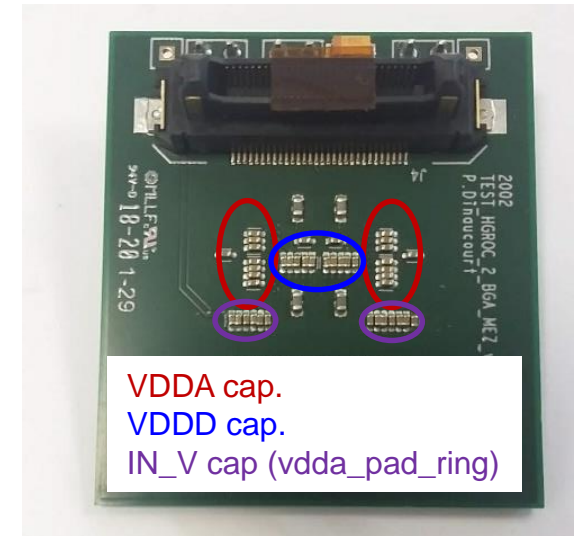


Digital coupling amplitude vs. channel

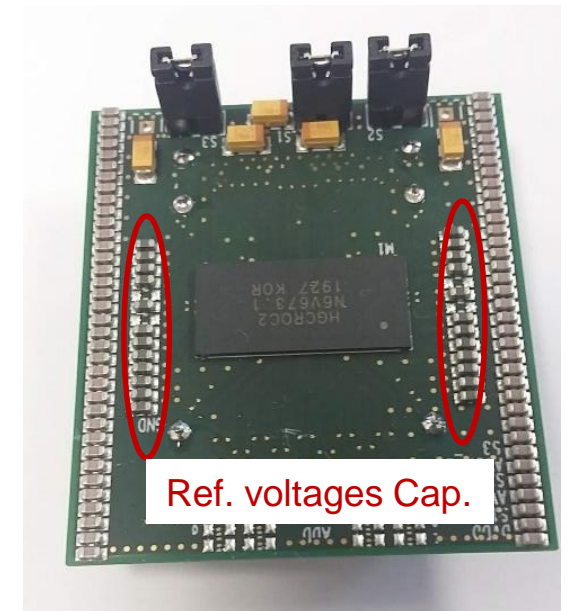




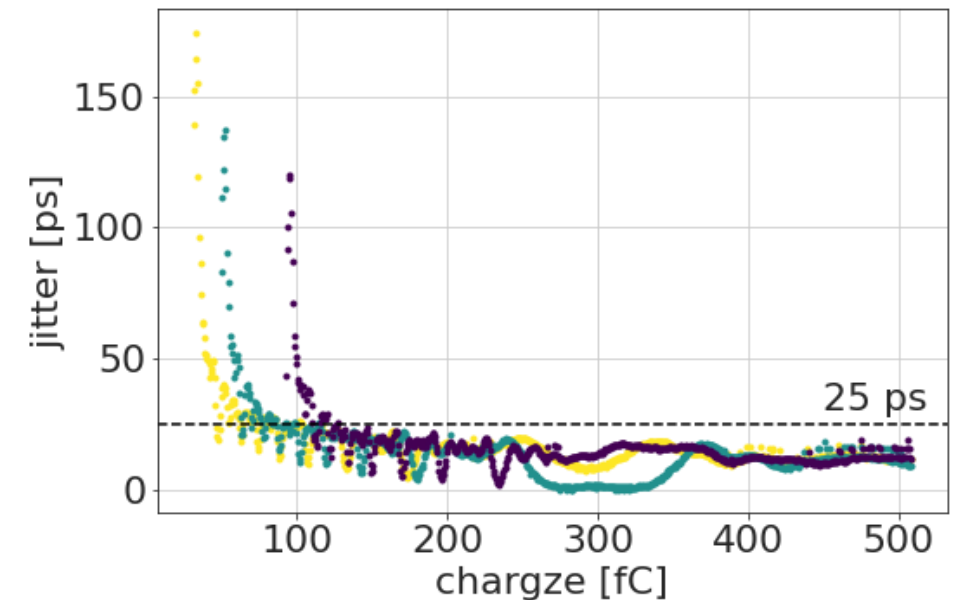
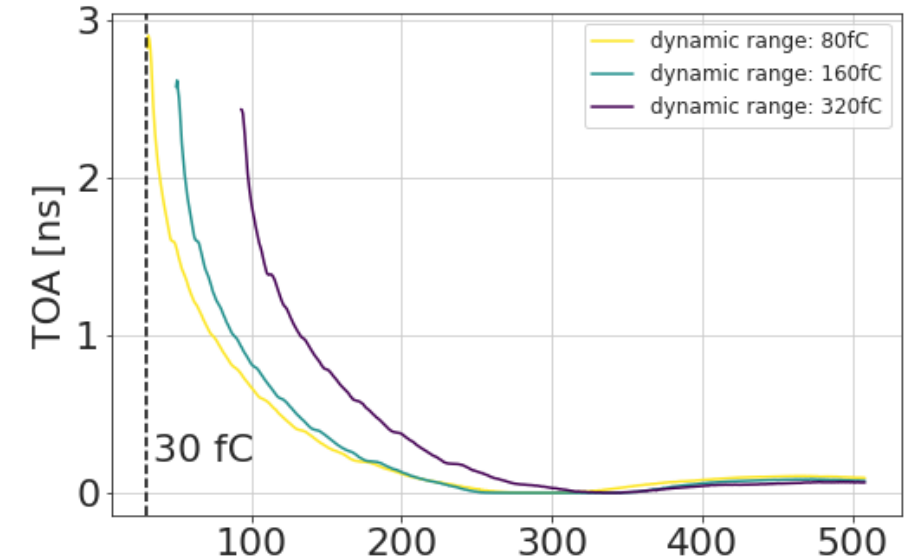
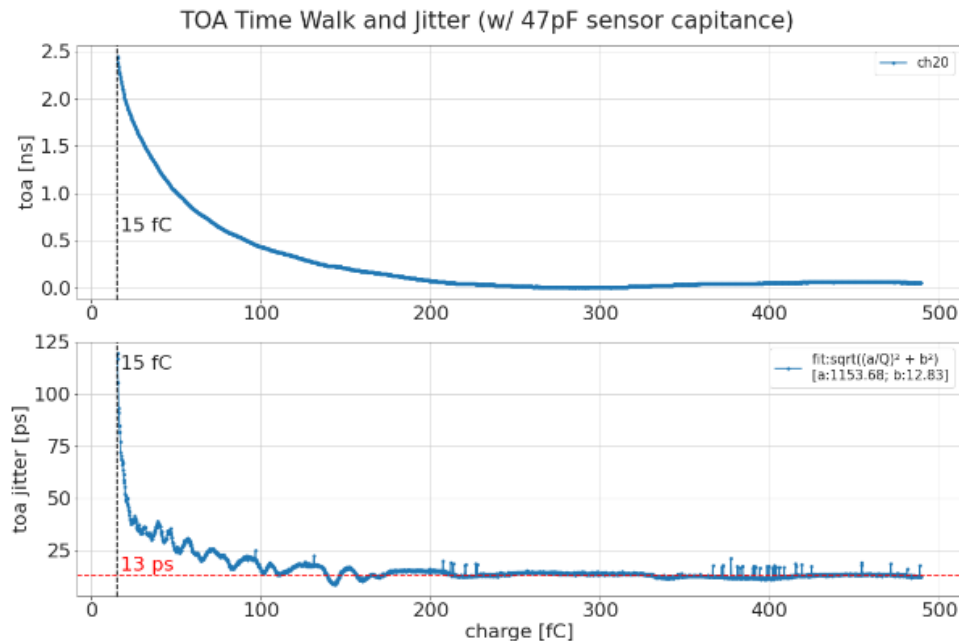
- Half0
- BGA4 [10*100nF D, 2*8*100nF A]
 - BGA1 [10*100nF D, 0nF A]
 - BGA2 [0nF D, 2*8*100nF A]
 - BGA3 [100nF D, 2*100nF A]
 - BGA4 [0nF D, 0nF A]



- Pk-Pk BGA1 [10*100nF D, 2*8*100nF A]
- Pk-Pk BGA2 [10*100nF D, 2*8*100nF A]
- Pk-Pk BGA3 [10*100nF D, 2*8*100nF A]
- Pk-Pk BGA4 [10*100nF D, 2*8*100nF A]
- Pk-Pk BGA1 [10*100nF D, 0nF A]
- Pk-Pk BGA2 [0nF D, 2*8*100nF A]
- Pk-Pk BGA3 [100nF D, 2*100nF A]
- Pk-Pk BGA4 [0nF D, 0nF A]

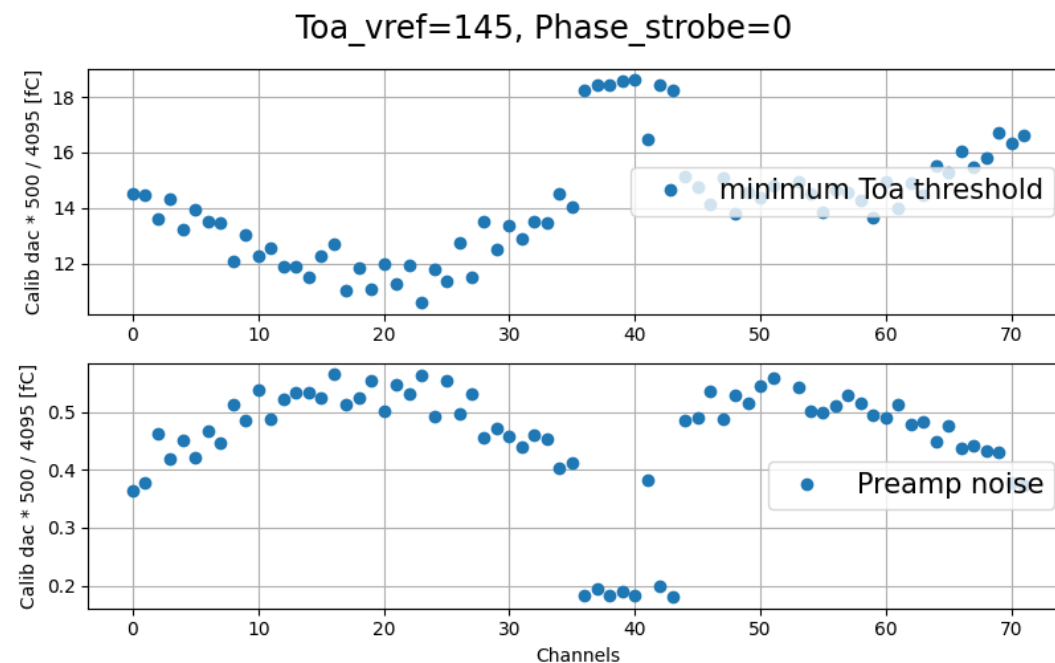
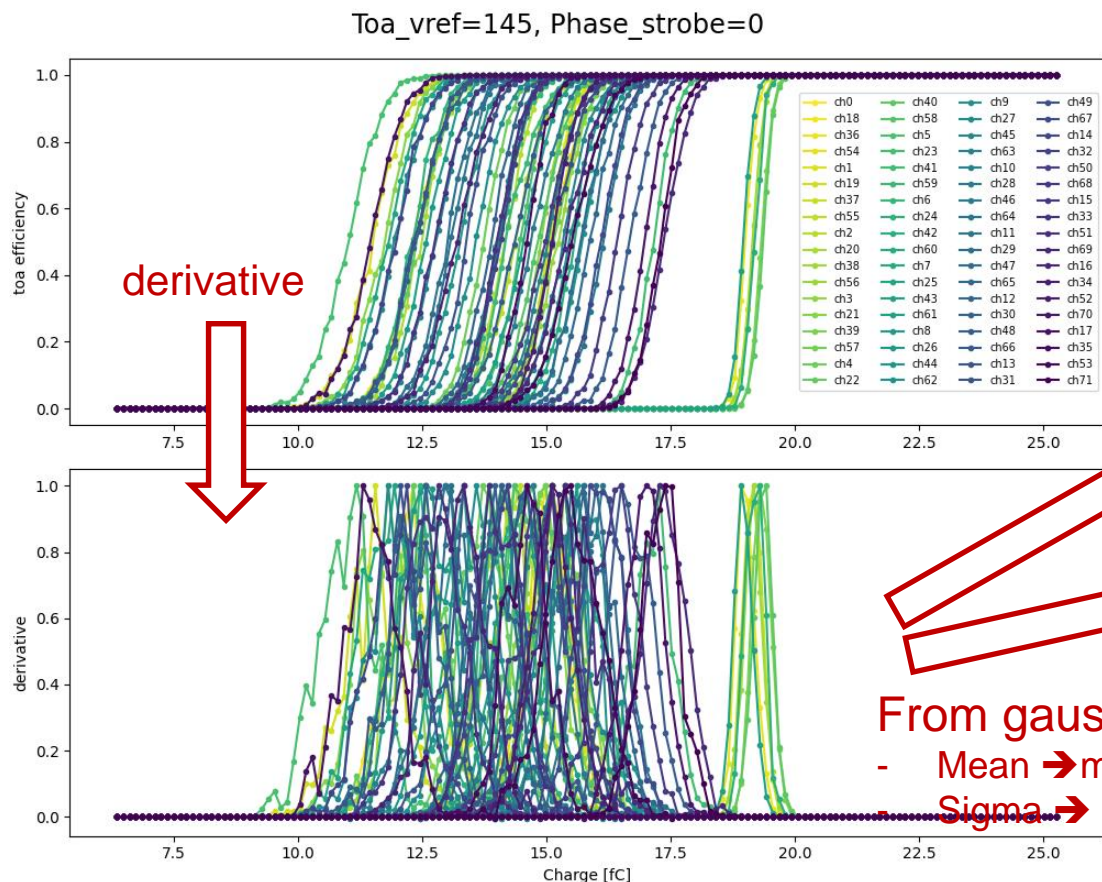


- Minimum threshold setting
 - Depending on the board, **limited by digital modulation on pedestals**
 - Min. achieved is 15 fC on characterization board
- Time walk
 - 2.5 ns
- Jitter
 - 1.15 ns/Q(fC)
 - 13 ps floor



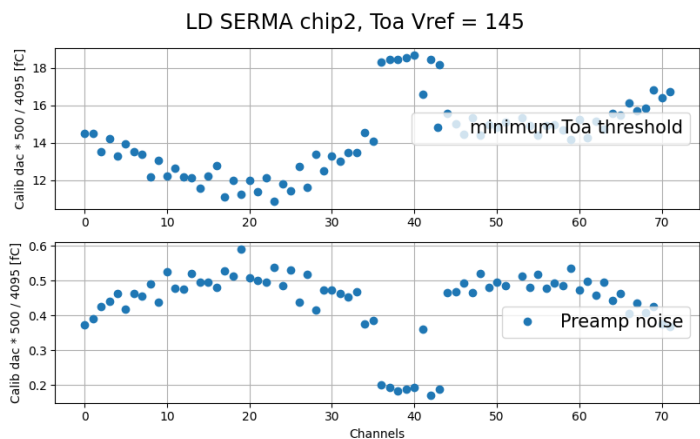
How to extract minimum toa and preamp noise?

S-curves: Toa efficiency as a function of the injected charge

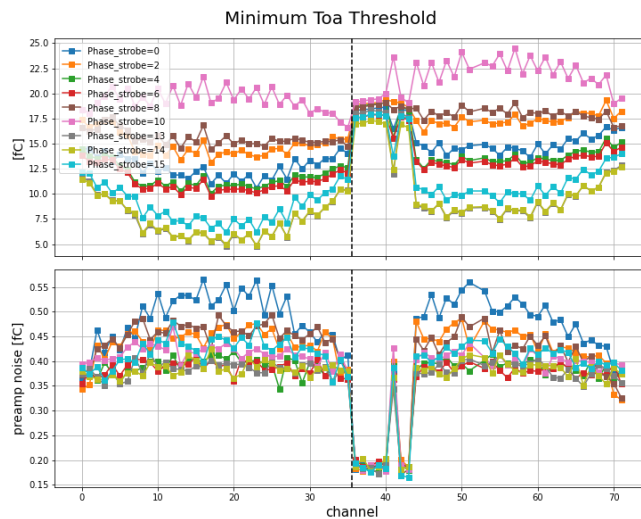


- 0,5 fC electronics noise at the preamp output → minimum Toa threshold should be just higher than 2,5 fC
- 12 fC is the best we achieved

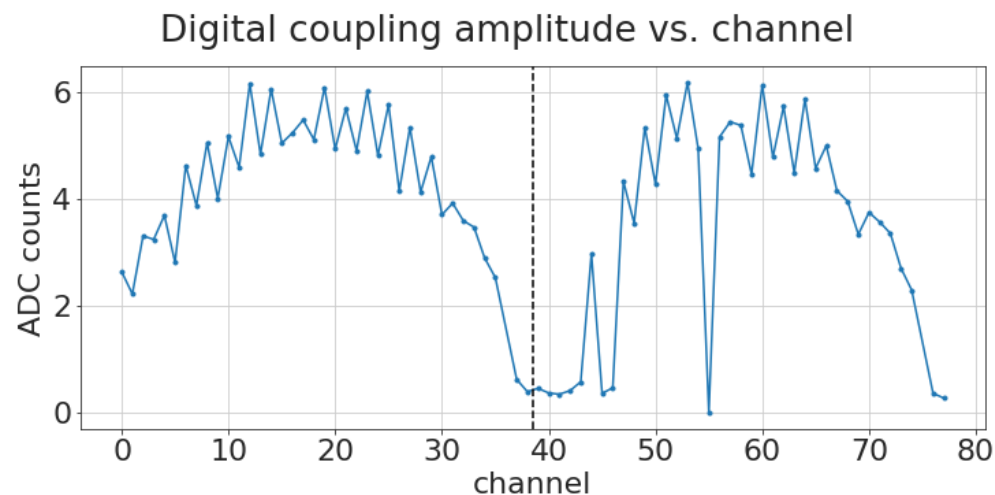
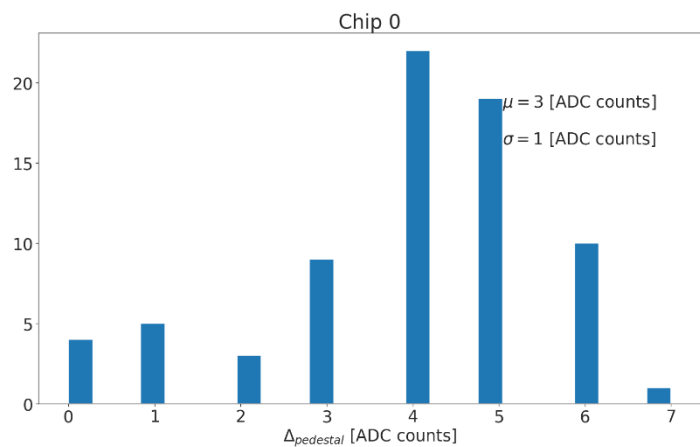
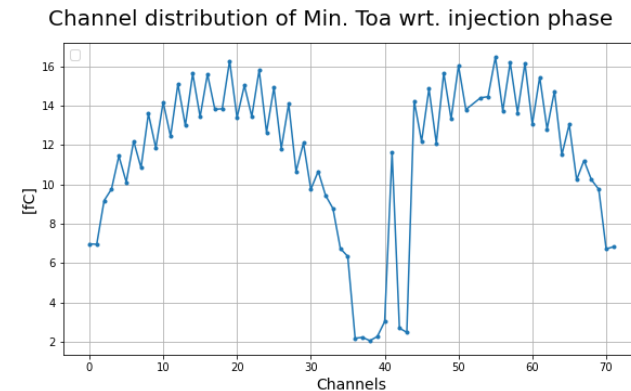
Digital noise: Preamp output vs. Shaper output



Injection phase = 0



Injection phase = 0 .. 15



Delta pedestal

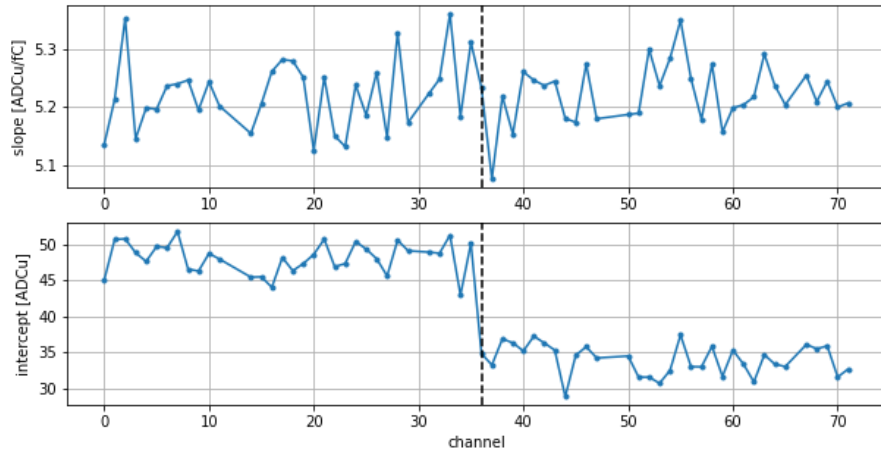
Shaper output:

- Gain = 0,2 fC/ADC
- Delta ped = 2 – 6 ADCs
- Delta_ped = 0,4 – 1,2 fC

Preamp Output

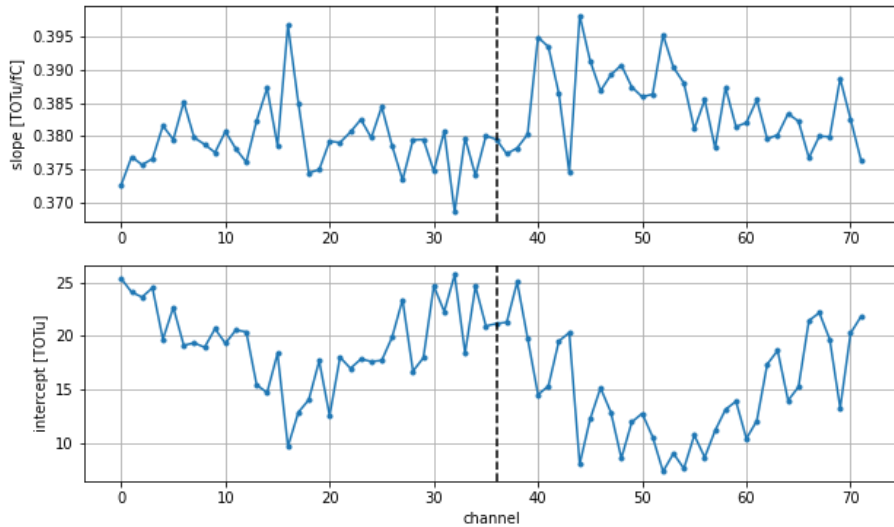
- Delta ped = 5 – 20 fC

ADC Slope and Intercept



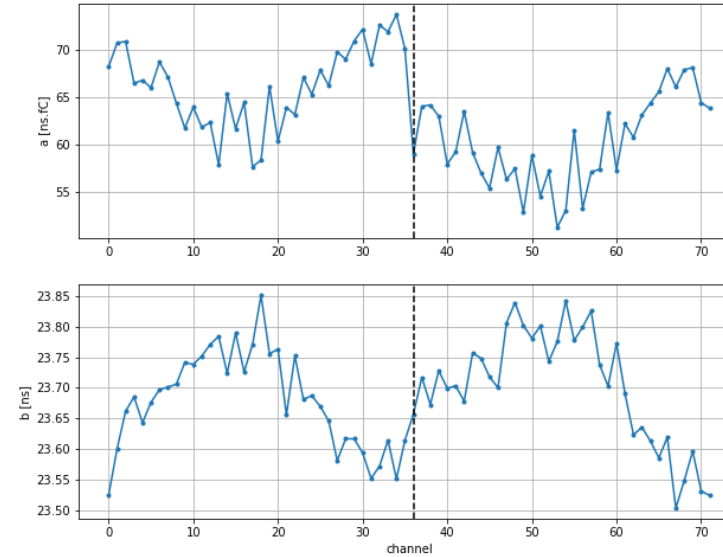
5.2 ADCu / ch
(+/- 2%)

TOT Slope and Intercept



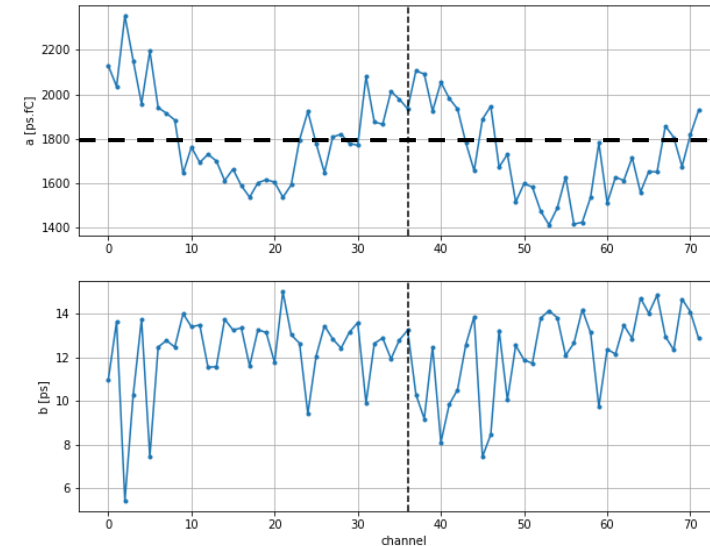
0.38 TOTu / ch
(+/- 3%)

TOA time walk a & b parameters of the a/Q + b fit



Clock
distribution
from the middle
of each half
visible on the
time walk
distribution

TOA jitter a & b parameters of the sqrt((a/Q)² + b²) fit

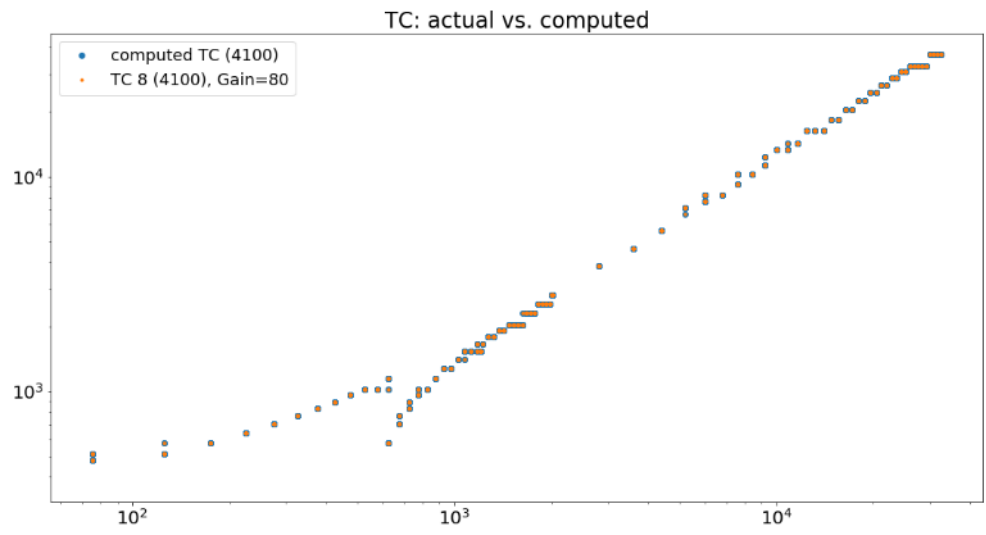
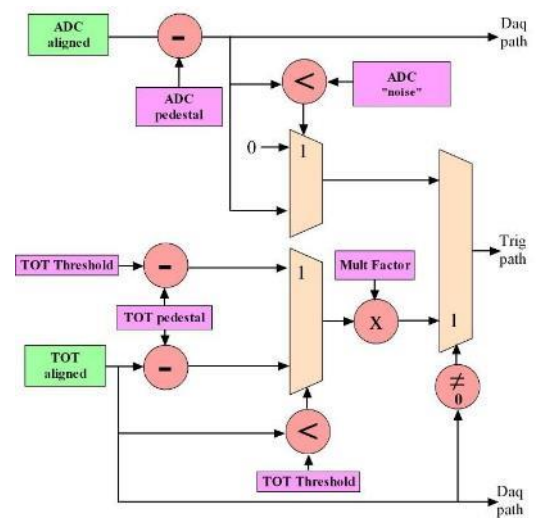
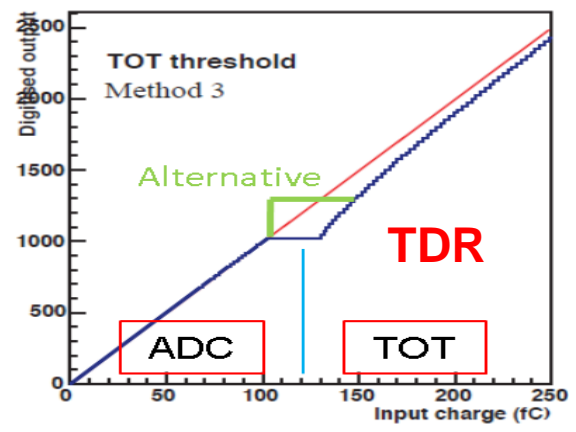
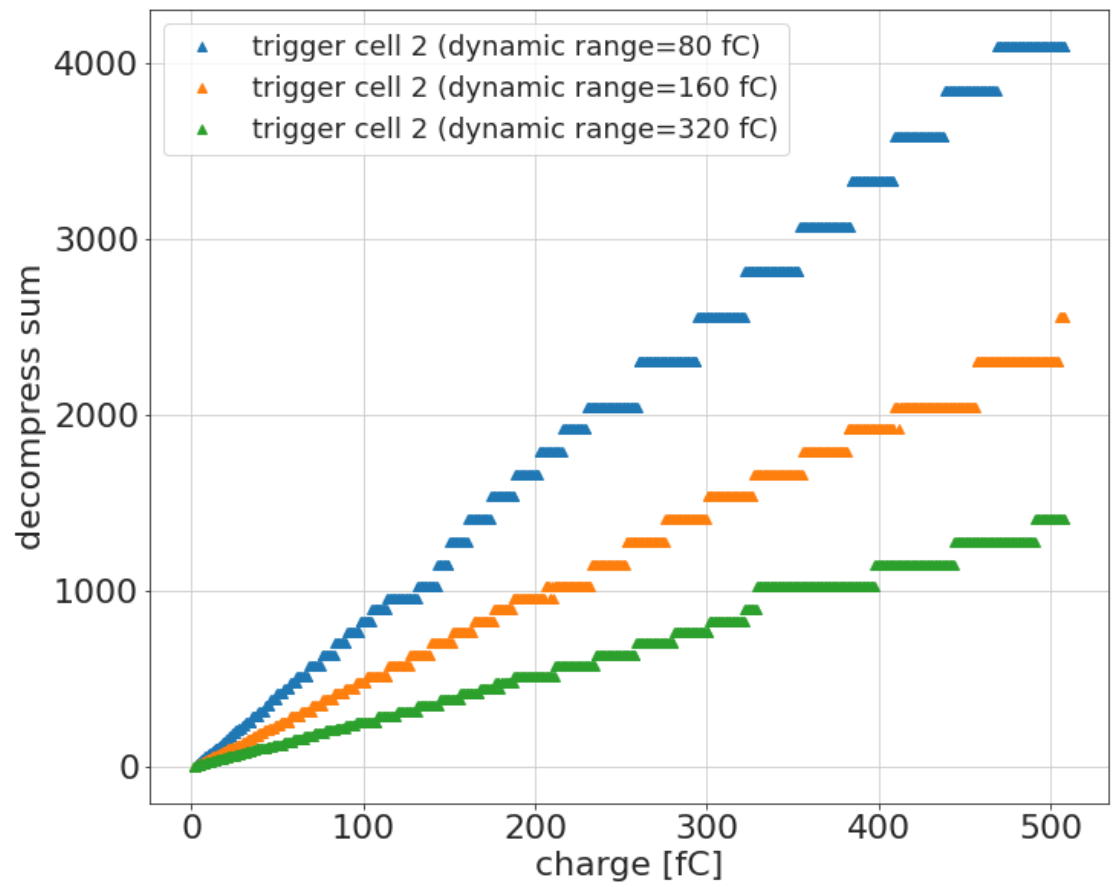


1.8 ns / Q(fC)

13 ps rms

Trigger path

- Charge linearization over ADC and TOT range
- Sum by 4 / 9 (19b / 21b)
- Compression: 4b exponent + 3b mantissa



H2GCROC3: the SiPM version of HGCROC3

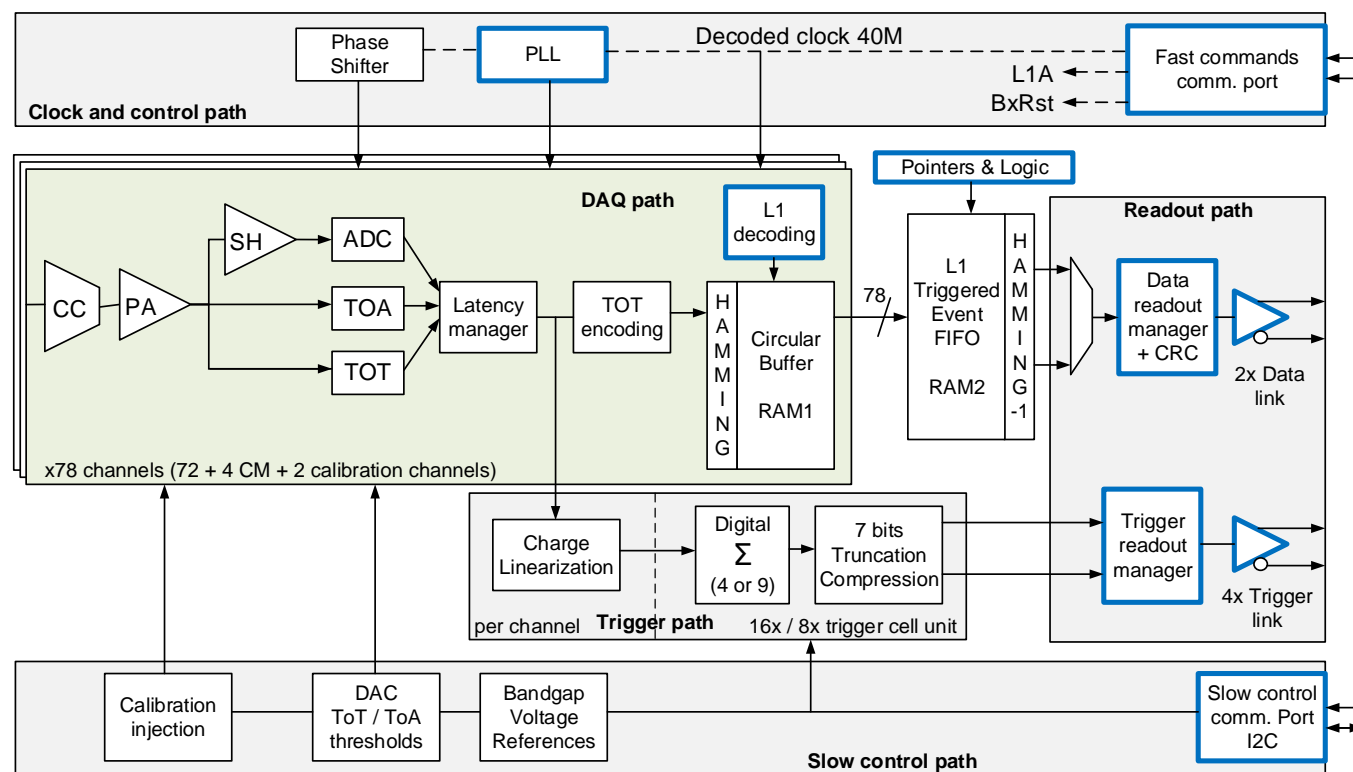
Differences on H2GCROC3

- 2,5 V power supply for the very front-end to cope with SiPM bias voltage
- Dynamic charge: **160 fC to 320 pC**
- Input DAC to tune the input voltage in order to compensate for breakdown voltage fluctuation
- Compensation of the leakage current up to **1mA**
- Radiation resistance up to **300 kRad**

Current Conveyor
based on KLAUS
chip from Heidelberg
UNI.

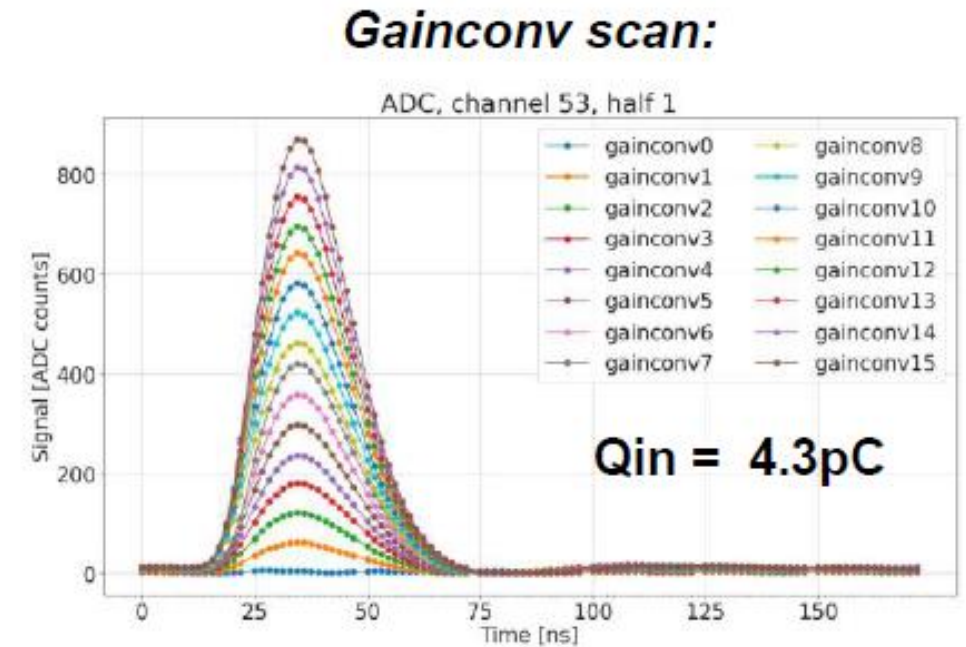
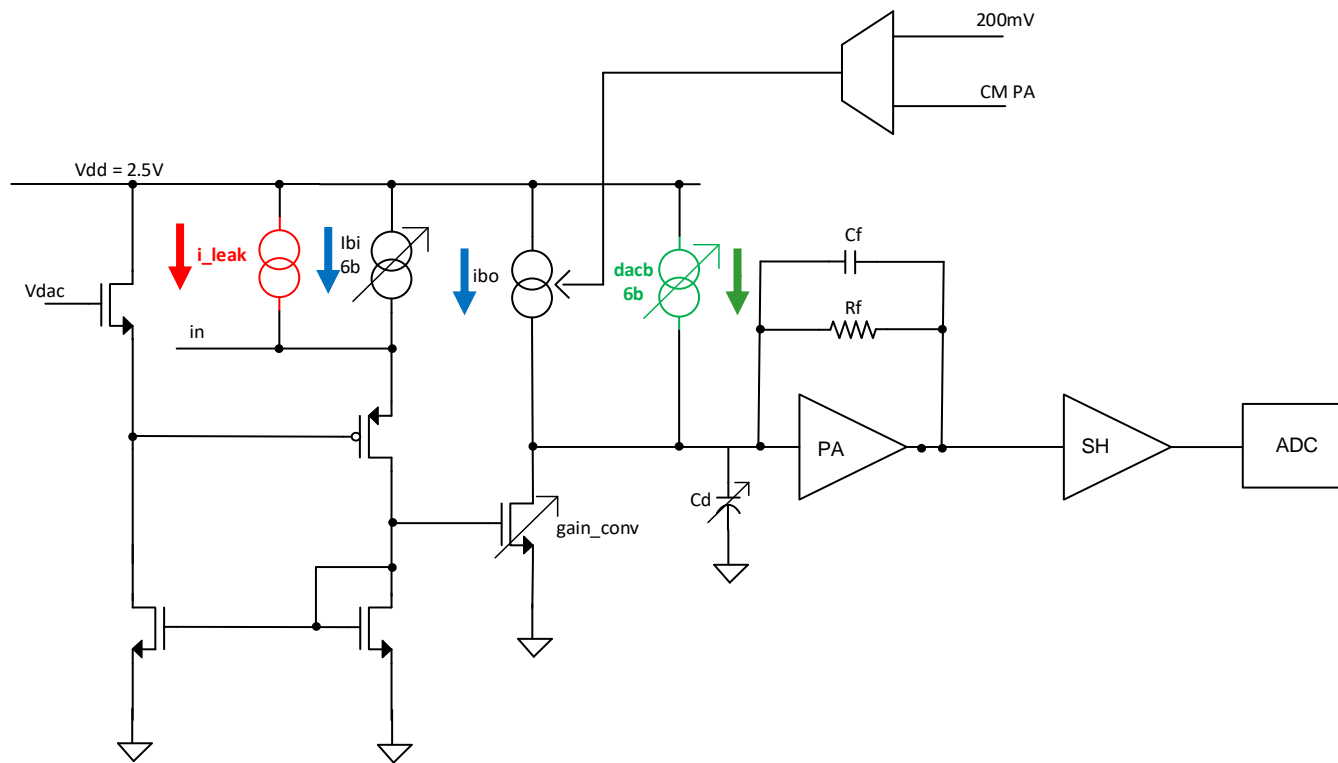
Attenuates the
current at the input
with 4 bits.

Gain: 0,025 to 0,375
(step 0,025)

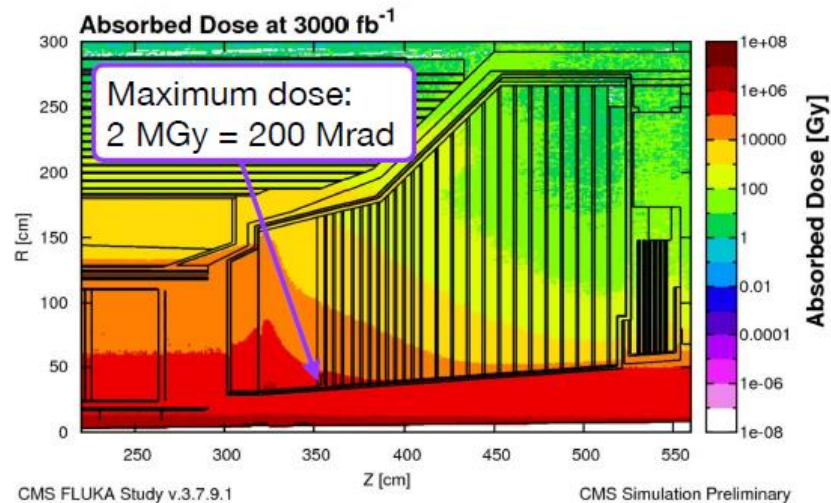


- **2 typical gains**

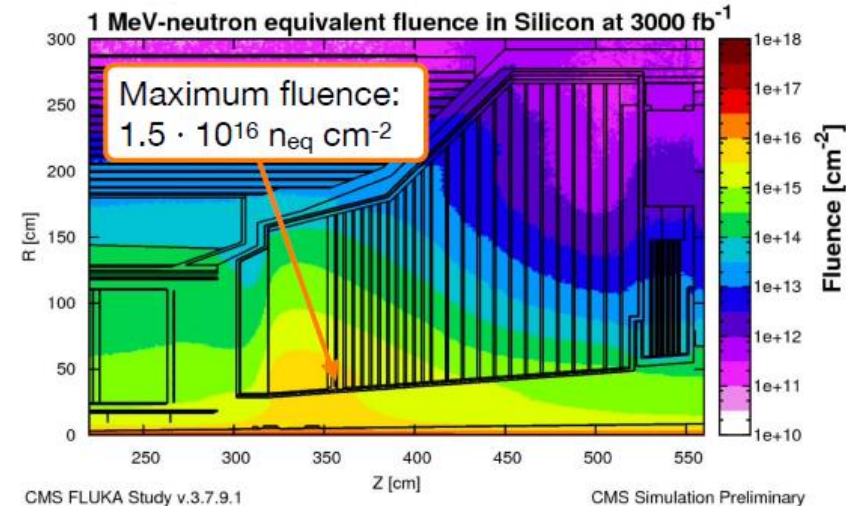
- Low gain (Physics mode): **44 fC/ADC gain, 50 fC noise (1.25 ADCu)**
- High gain (Calibration mode): **10 fC/ADC gain, 20 fC noise (2 ADCu)**



- According to FLUKA simulations, the CMS forward region will be exposed to a total integrated dose of up to ~ 200 Mrad and a hadron fluence up to $1,5 \cdot 10^{16} n_{eq} cm^{-2}$
- Irradiation campaigns required to demonstrate that HGCR0C3 withstands such harsh radiation environments

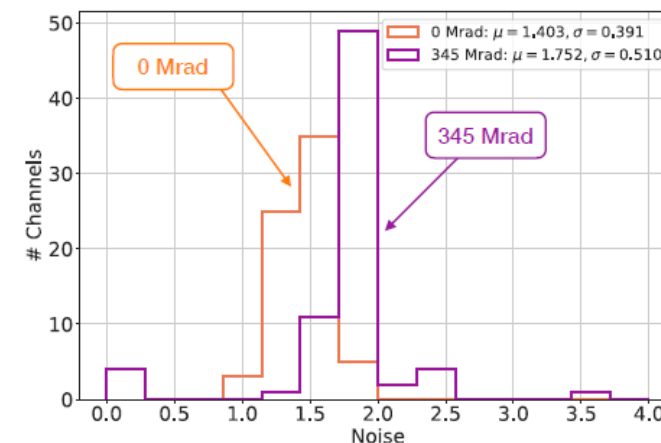
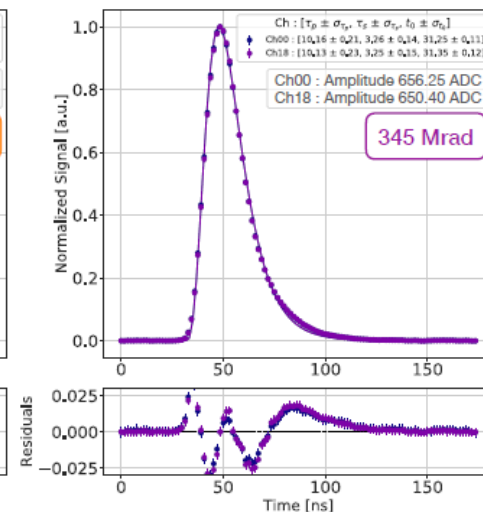
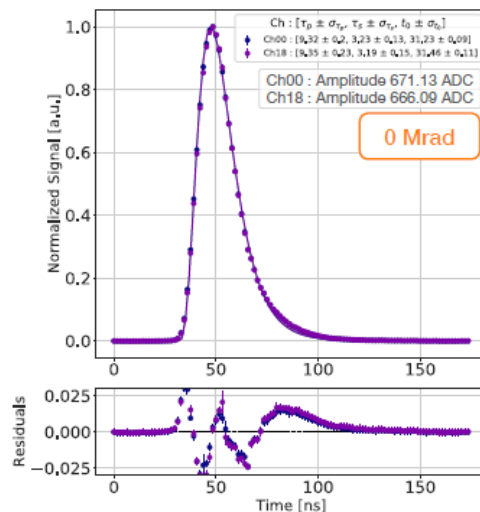
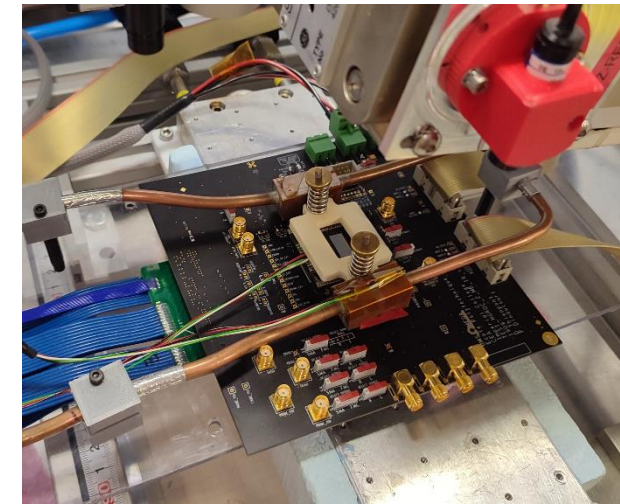


Total Ionising Dose (TID): test the cumulative damage of ionising particles

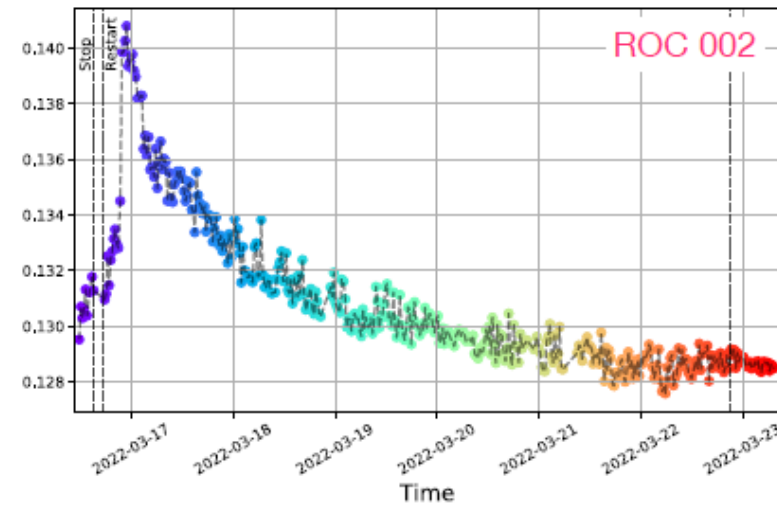
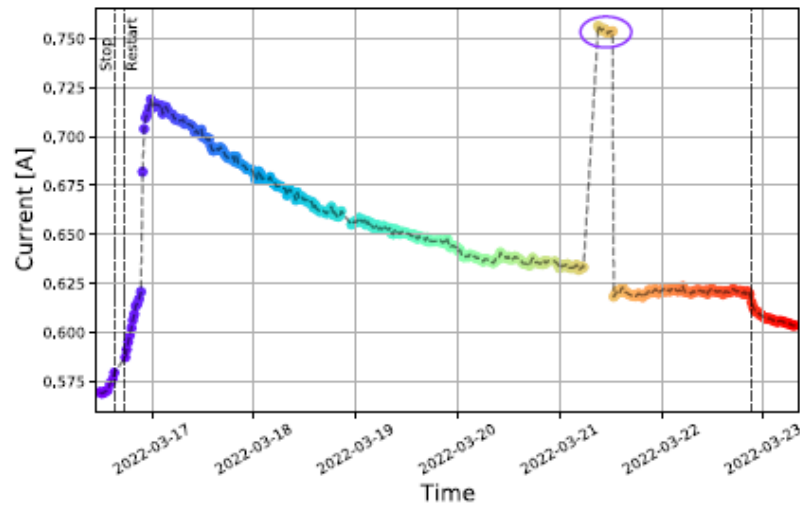
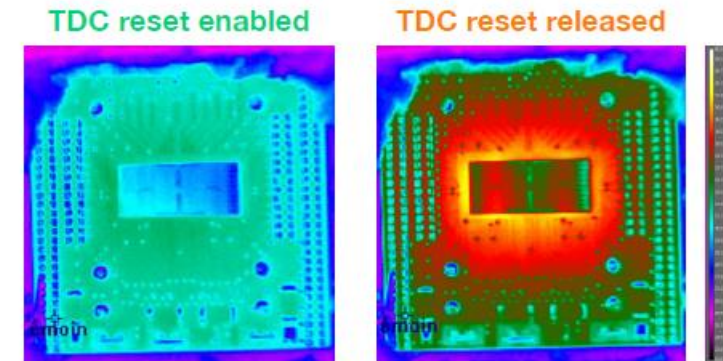


Single Event Effect (SEE): test the non-cumulative damage induced by single particles

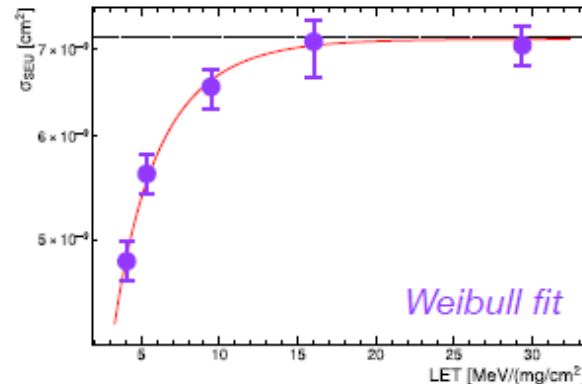
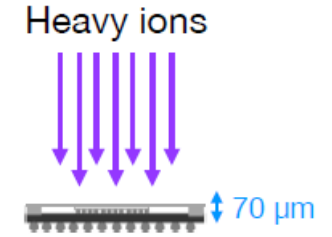
- The chip was placed on a **mezzanine** and **thinned** to $\sim 70 \mu\text{m}$
 - *Beam*: 10 keV X-rays (Obelix facility at CERN)
 - *Temperature*: -10°C
 - *Dose rate*: 0.245 and 2.45 Mrad/h
 - *Total integrated dose*: **345 Mrad**
- **No big impact** observed on any part of the chip:
 - *No change in the **charge** and **time** measurement (linearity and jitter)*
 - *No misbehaviour in **DRAM***
 - *Preamplifier **noise** slightly increase with dose: $\sim 20\%$ (1800 e⁻ to 2200 e⁻)*
 - ***PLL**, **e-links** and **digital** part maintain the good performance as expected*
 - *Power consumption increase (next slide)*



- Analog and digital **currents increase** in the initial phase of the irradiation:
 - analog: +25% → *unexpected*
 - digital: +8% → *expected due to current leakage in the transistors*
- *Current increase traced to TDC with thermal camera*
 - *Extra current is removed when resetting the TDC, comes back when releasing the reset*
 - *Identified floating node in the TDC digital block when in idle mode (not disturb time measurement)*

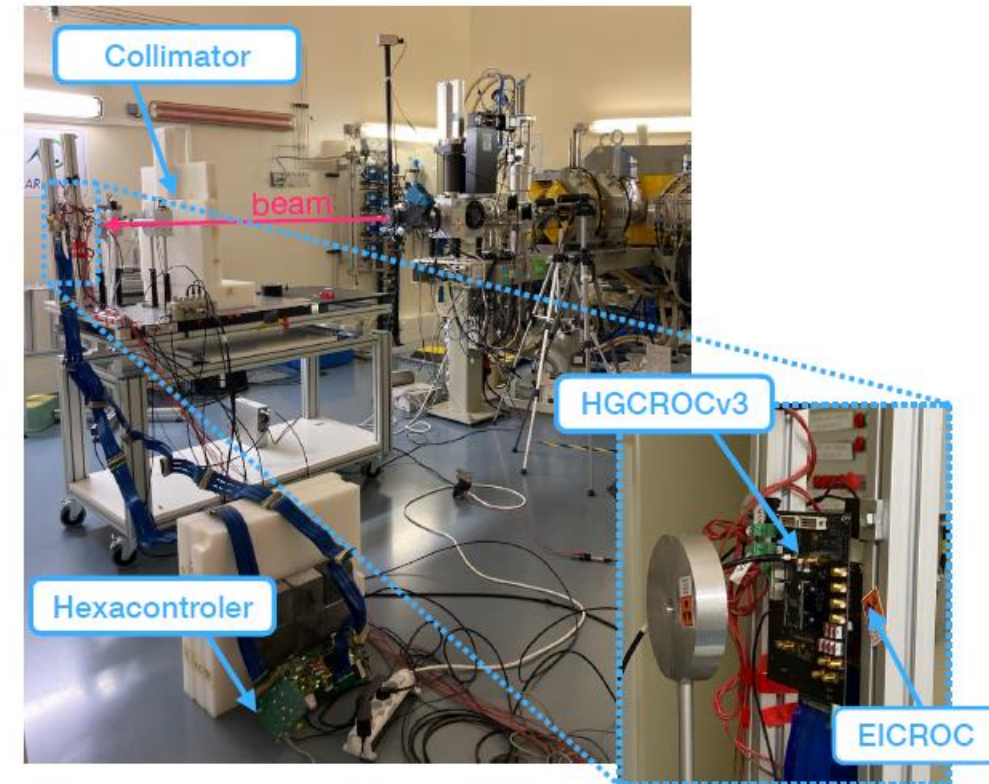


- Test the stochastic **non-cumulative** radiation **damage** induced by single particles: 3 possible consequences
 - *Single Event Upset (SEU) : digital error, bit flip (0→1 or 1→0)*
 - *Single Event Transient (SET) : analog error, bit shift*
 - *Single Event Latch up (SEL) : permanent damage*
- Irradiation of HGCROC3 chip with **heavy ions** at UCL cyclotron in Louvain
 - *Beam: low energy heavy ions with different **Linear Energy Transfer (LET)***
 - *Flux: 10^4 particles/(s·cm²)*
 - *Temperature: 7.2° C*
- Two main measurements:
 - *Configuration: I2C registers*
 - *Digital & memory: DAQ tests*



Ion	M/Q	Range [μm Si]	LET [MeV/mg/cm ²]
Ne	3.14	202.0	3.3
Al	3.37	131.2	5.7
Ar	3.33	120.5	9.9
Cr	3.31	107.6	16.0
Ni	3.22	100.5	20.4
Kr	3.35	94.2	32.4
Xe	3.54	73.1	62.5

- **Proton** irradiation campaigns at *Arronax* in Nantes (22nd December 2022, 3rd February 2023)
 - *Beam*: 64 MeV protons
 - *Flux*: 10^{10} particles/s/cm² (expected at HL-LHC: 10^6 p/s/cm²) (continuous mode: packets every 33ns)
 - *Duration*: 12*2 hours
 - *Temperature*: room temperature
 - *Total integrated dose*: 140 Mrad
- **Complex experimental setup**:
 - Long cables to protect the hexacontroller
 - No access to the cavern for days (activation)
- **HGCAL** radiation environment dominated by light hadrons
 - more **realistic** description of the HGCROC3 behaviour
 - higher flux and more error **statistics**

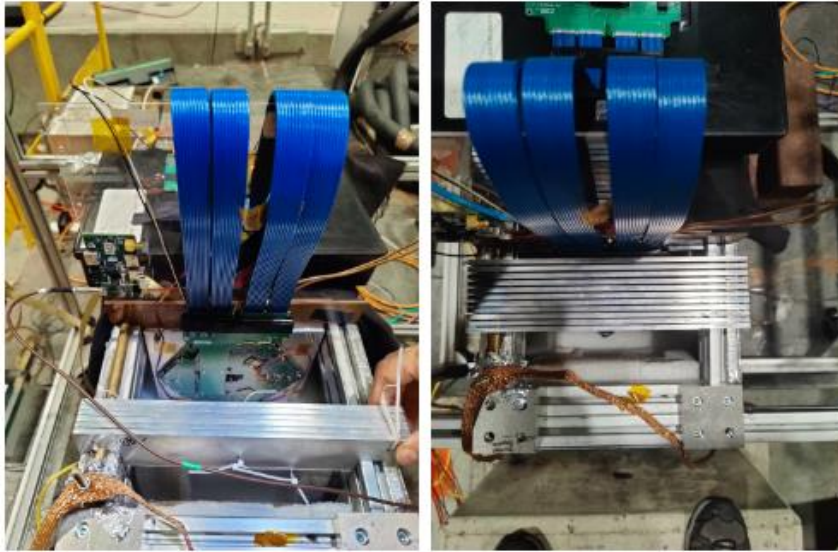


- Heavy ions results
 - No SEL
 - No I2C bitflips (when AutoReload enable)
- Protons results
 - Flux = $2.20 \cdot 10^{10} \text{ s}^{-1} \cdot \text{cm}^{-2}$, total time = **13 h** → ~ 10 years of HL-LHC

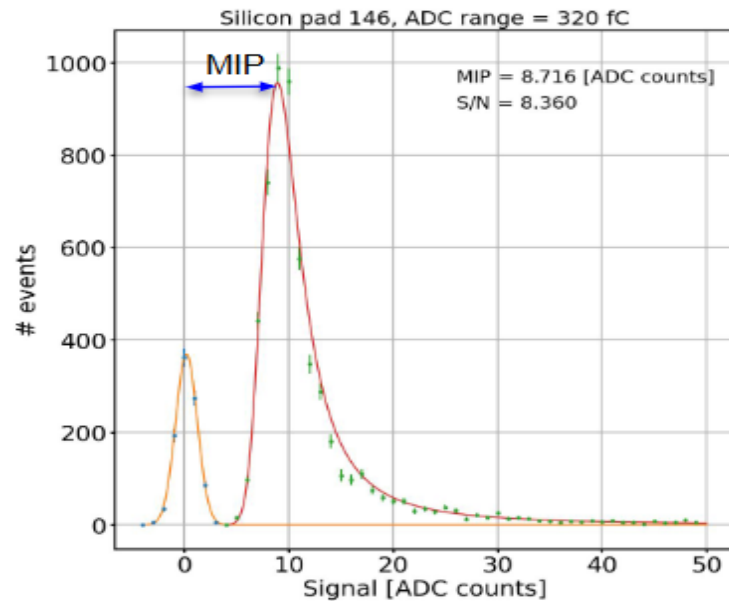
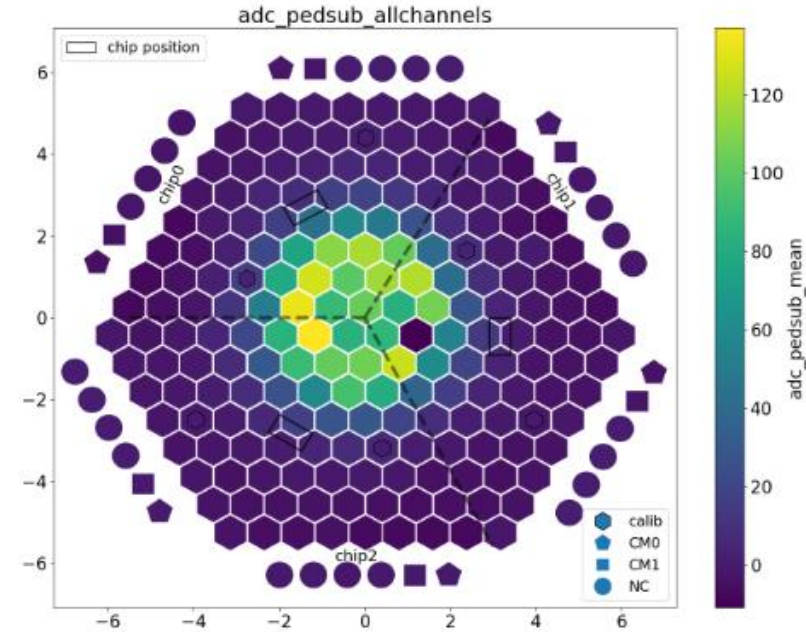
	SEU counters	SEU trigger	SEU CRC	SEU memory	Short SET	Long SET
# errors	< 1	38	30	127	85	190
DAQ time	13.011 h	34 s	340 s	4352 s	340 s	13.011 h
Rate A_{rronax} [err/s]	$< 2.1 \cdot 10^{-5}$	1.12 ± 0.18	0.09 ± 0.01	0.029 ± 0.002	0.25 ± 0.03	0.0041 ± 0.0003
Rate $H_{\text{GCAL av}}$ [err/s]	$< 1.9 \cdot 10^{-9}$	$(1.0 \pm 0.2) \cdot 10^{-4}$	$(8.1 \pm 1.6) \cdot 10^{-6}$	$(2.6 \pm 0.2) \cdot 10^{-6}$	$(2.2 \pm 0.3) \cdot 10^{-5}$	$(3.6 \pm 0.3) \cdot 10^{-7}$
Rate $H_{\text{GCAL max}}$ [err/s]	$< 1.9 \cdot 10^{-8}$	$(1.0 \pm 0.2) \cdot 10^{-3}$	$(8.1 \pm 1.6) \cdot 10^{-5}$	$(2.6 \pm 0.2) \cdot 10^{-5}$	$(2.2 \pm 0.3) \cdot 10^{-4}$	$(3.6 \pm 0.3) \cdot 10^{-6}$
Rate $A_{\text{ll chips}}$ [err/s]	< 0.00019	10 ± 2	0.81 ± 0.16	0.26 ± 0.02	2.2 ± 0.3	0.036 ± 0.003
Cross section [cm^2]	$< 9.7 \cdot 10^{-16}$	$(5.7 \pm 0.9) \cdot 10^{-11}$	$(4.5 \pm 0.8) \cdot 10^{-12}$	$(1.5 \pm 0.1) \cdot 10^{-12}$	$(1.3 \pm 0.1) \cdot 10^{-11}$	$(2.1 \pm 0.1) \cdot 10^{-13}$

- For each chip (on average): 1 link loss / 2.5 years
- For HGICAL (on average): 1 link loss / 2 min

V3-LD hexaboard with 300 μm thick sensor



250 GeV electron, default gain, with absorber

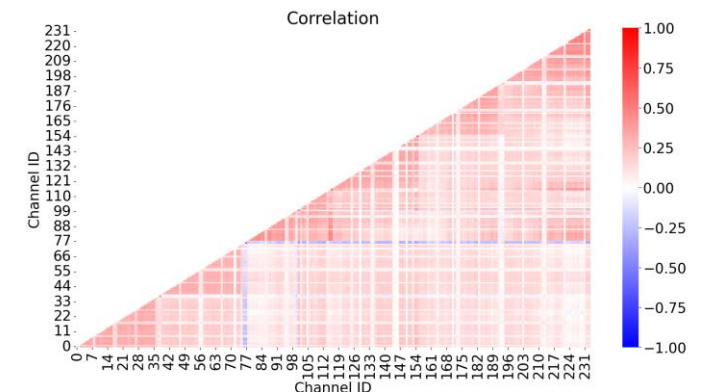
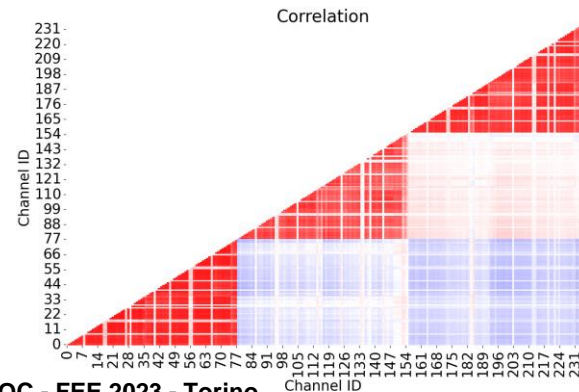


NSH HB module (Oct. 21) vs. V3-LD module (Oct. 22)

Digital noise:

> 120 ADCu

~10 ADCu

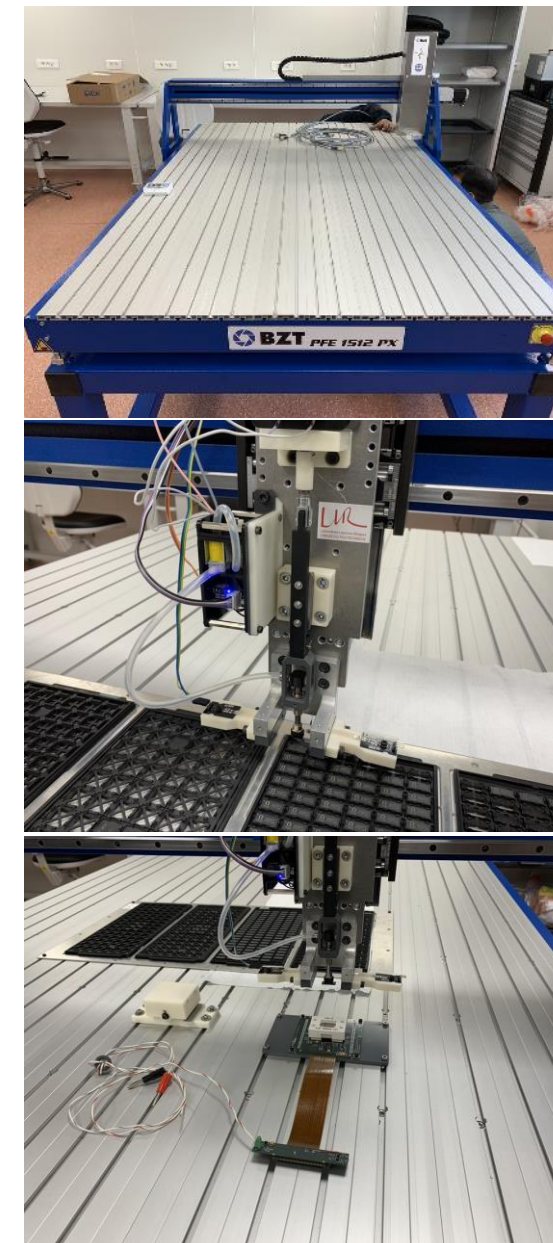


- HGCROC3 for HGICAL has been extensively measured and reaches good performance
 - $< 1\%$ linearity for charge measurement over the full dynamic
 - Noise level as expected
 - Timing (Time walk and jitter) as expected: TW < 1.4 ns, jitter ~ 1.8 ns/Q(fC) and 13 ps floor
- But still need to fight against digital activity
 - Digital « noise » on pedestals
 - Lower Toa threshold 15 fC (24 fC for the module)
- HGCROC3 is radiation tolerant
 - Still working properly up to ~ 400 Mrad
 - 20% noise increase not understood yet
- Main concern now is the packaging
 - HD and LD
 - Common or separated grounds

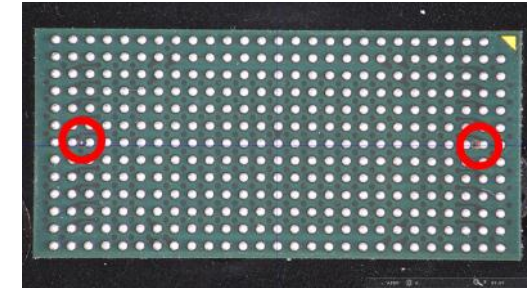
- 2 robots: LLR and OMEGA
- Pick and placing features work
- DAQ and analysis software work
- ~ 450 HD-ROCV3 have been tested
- ~ 300 LDROCV3 have been tested

Preliminary tests list:

- Power consumption
- Write/read fuse number
- Write/read the 8 bits of the 800 SC registers
- Measure the 2×64 probe_dc values
- Measure the 10bits DACs and 12 bits calibration
- Measure the 6 bits channel wise tuning dacs : 78×6 bits $\times 3$ dacs
 - Adjust the pedestals, TOA/TOT thresholds channel wise
- Check the fast commands and links
- Check rms to detect bad or unconnected channels
- Make a phase scan to check shifter OK
- Run the DRAM tests
- Check ADC linearity with test pulse injection : 10 points $\times 72$ channels $\times 100$ meas.
- Set threshold to ~ 10 fC measure TOA and TOT vs Q_{inj} (DAQ and TRIG paths)
- **Specific tests for the SiPM version**
 - 2V5 power consumption
 - Input DC level adjustment (Input DAC)
 - Conveyor gain (DACb adjustment)

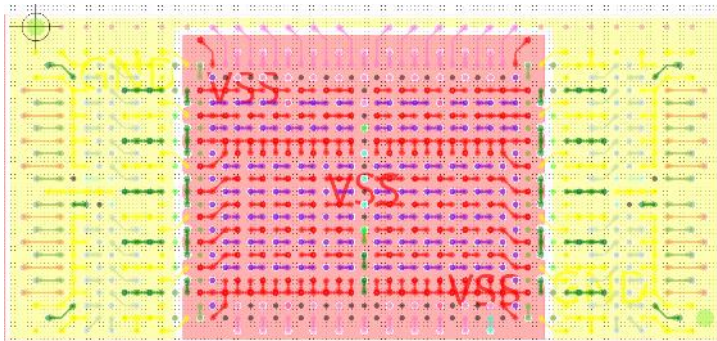


- High density Si-version HGCROC3
 - Short circuit in the BGA substrate (vdd_pad tied to ground)
 - ~ 2000 drilled packages
 - ~ 150 pieces tested: > 90 % short circuit removed
 - Tests with packages on Mezzanine, production testboard works, robot in progress at LLR
- Module performance
 - NSH HD HB: good with HDROCv2, terrible with HDROCv3
 - Waiting for results with HDROCv3 mounted on V3 HD HB
 - But most likely, should go back to « HGCROC2 » package with separated gnda/vss

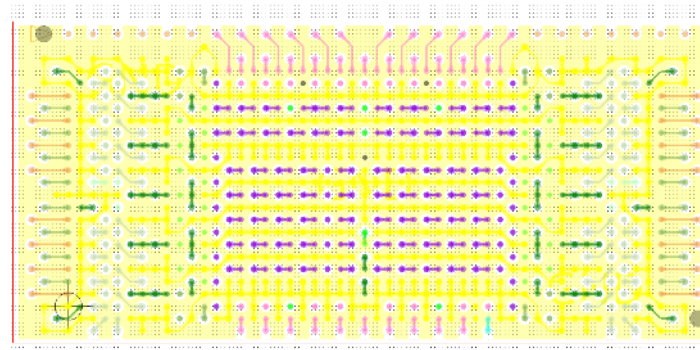


		noise	delta pedestal
ROCv2	bare NSH HB	1,3	3
	module	2,5 - 3	16
ROCv3	bare NSH HB	1	16
	module	> 2,5	> 170

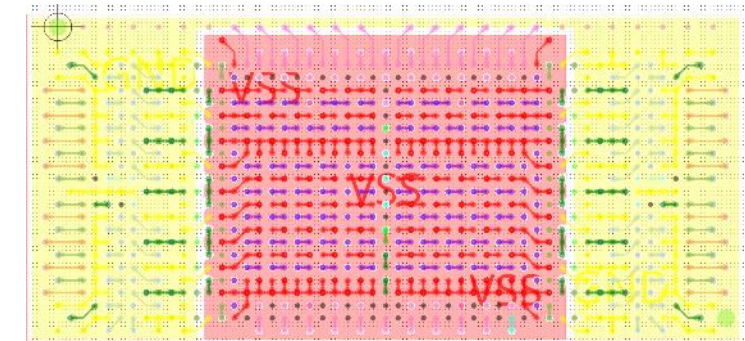
HGCROC2



HGCROC3

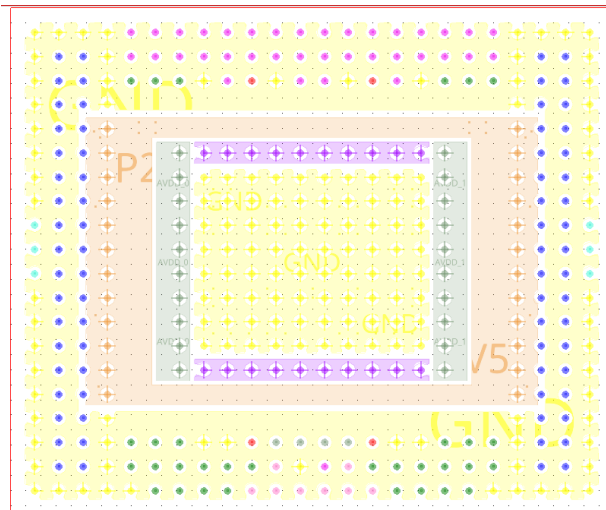


HGCROC3b (not yet in fabrication)

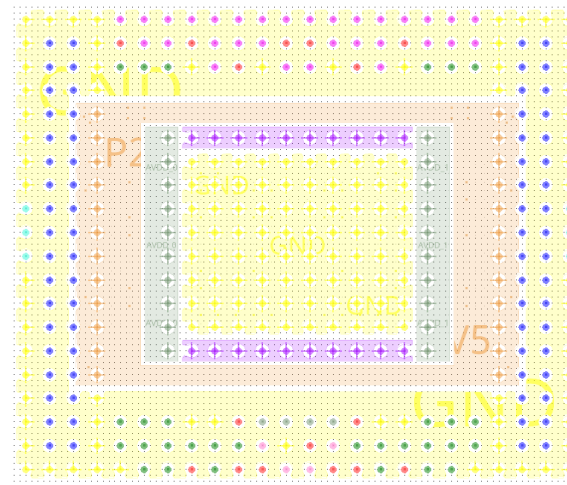


- Low density Si-version HGCROC3
 - ~ 10 pieces mounted in the first version of LD substrate (SERMA)
 - request laser drilling
 - Incompatible for H2GCROC3
 - ~ 50 pieces mounted in the corrected LD substrate (SERMA)
 - Compatible for both HGCROC3 and H2GCROC3
 - New batch of 1000 substrate arrived these days at OMEGA
 - All H2GCROC3
 - Waiting for results with LDROCV3 mounted on V3 LD HB
 - New LD packaged with gnda/vss separated sent to fabrication to NCAP (China)
 - Expected back in 2-3 months

HGCROC2



HGCROC3



New HGCROC3
(fabrication on-going)

